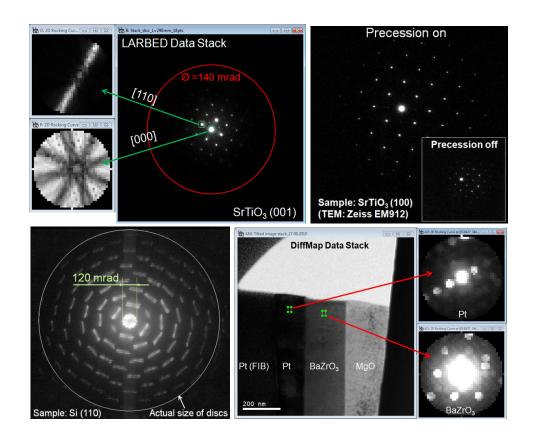
QED for DigitalMicrograph

Large-Angle Rocking-Beam Electron Diffraction (LARBED)

Precession Electron Diffraction (PED)

Diffraction Mapping (DiffMap)

Fluctuation Electron Microscopy (FEM)



QED Manual 1.5.6

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1. Introduction:

This QED Manual describes the capabilities and usage of the QED Plug-in for Gatan DigitalMicrographTM (DM). After giving a short overview of the techniques made available by this plug-in, its usage will be described in detail. A *Quick Reference Guide* explaining the function of each menu and GUI item may be found at the end of this manual.

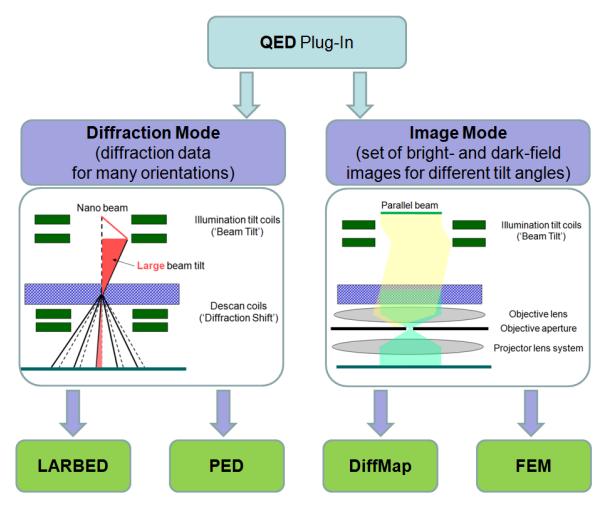


Figure 1: Diagram of TEM/diffraction techniques facilitated by the QED plug-in. While the setup in diffraction mode should be done with a narrow but not highly convergent beam (e.g. in nano-beam diffraction (NBD) mode), in image mode the sample is illuminated by a parallel beam, using the objective aperture to select the reciprocal space resolution.

The QED plug-in provides a number of TEM techniques each of which delivers a specific kind of diffraction information. Figure 1 lists the main acquisition techniques and associated basic data reduction functionality made available by the QED plug-in. More sophisticated data analysis methods are provided by the QEDAnalysis plug-in, which is currently under development.

All of the 4 techniques listed in Figure 1 have been described in the literature. We will therefore not explain them here in detail but only very shortly, pointing to resources for obtaining more detailed information. It is certainly possible to use this plug-in for acquiring the data necessary

to obtain information very different from the one targeted by these 4 techniques. The following list therefore only serves to provide a rough idea of what this plug-in can be used for.

Large-angle rocking-beam electron diffraction (LARBED): This diffraction technique provides information very similar to convergent beam electron diffraction (CBED) but for 'semi-convergence angles' up to (and on some microscopes even in excess of) 100 mrad. This is achieved by recording the different incident beam directions sequentially, instead of in parallel as in the case of CBED using a convergent beam. This technique therefore allows quantitative, background-subtracted CBED-like data to be recorded for crystalline samples that are too thin or have unit cells too large to allow the meaningful application of CBED.

The effect of aberrations and imperfect beam tilt/beam shift separation of the illumination system of the microscope may cause the diffraction spot to illuminate very different regions of the sample for such large beam tilt angles. The QED plug-in therefore implements a sophisticated, fully automated technique for measuring and compensating for these effects, so that all diffraction data indeed stems from the position selected by the user. Further details on the LARBED technique may be found in the references provided below, especially the first one.

- 1. C. T. Koch, *Aberration-compensated large-angle rocking-beam electron diffraction*, Ultramicroscopy 111 (2011) 828-840
- 2. C. T. Koch, P. Bellina, P. van Aken, *Software precession electron diffraction*, in: 14th European Microscopy Congress (EMC) in Aachen, Vol. 2: Materials Science, Springer, Berlin Heidelberg, 2008, pp. 201–202.
- 3. C. T. Koch, *Method and device for measuring electron diffraction of a sample*, United States Patent US 8,076,640 B2.

Precession electron diffraction (PED): This technique has been established in 1994 (see the first reference below) and is already associated with quite a large number of published papers. Thus, the references provided below are only a small selection. PED provides electron diffraction data, which can more readily be analyzed using kinematic scattering theory (or rather 2-beam or many-beam theory – see Ref. 8). PED patterns are also relatively insensitive, within a few mrad, to the precise specimen orientation.

The QED plug-in allows the aberration-compensated acquisition of PED patterns by summing up a set of diffraction patterns recorded at a discrete set of beam tilts on a circle. Because of the time for the microscope to respond to remote control commands, this finite sampling is certainly much slower than the continuous sampling provided by a dedicated hardware solution as described in some of the references below (Refs. 1-6). However, the dynamic compensation of aberrations featured by the QED plug-in and the high dynamic range achievable by summing up multiple CCD exposures may compensate this deficit to a large degree.

- 1. R. Vincent, P. A. Midgley, *Double conical beam-rocking system for measurement of integrated electron diffraction intensities*, Ultramicroscopy 53 (1994) 271–282.
- 2. M. Gemmi, *Precession technique*, in: J. Puiggali, A. Rodriquez-Galan, L. Franco, M. T. Casas (Eds.), Electron crystallography and cryo-electron microscopy on inorganic

- materials and organic and biological molecules, Barcelona:Universitat Politecnica De Catalunya, 2001, p. L91L97.
- 3. S. Nicolopoulos, J. P. Morniroli, M. Gemmi, *From powder diffraction to structure resolution of nanocrystals by precession electron diffraction*, Z. Kristallogr. Suppl. 26 (2007) 183–188.
- 4. A. Avilov, K. Kuligin, S. Nicolopoulos, M. Nickolskiy, K.Boulahya, J.Portillo, G. Lepeshov, B. Sobolev, J. P. Collette, N. Martin, A. C. Robins, P. Fischione, *Precession technique and electron diffractometry as new tools for crystal structure analysis and chemical bonding determination*, Ultramicroscopy 107 (2007) 431–444.
- 5. C. S. Own, L. D. Marks, W. Sinkler, *Electron precession: a guide for implementation*, Rev. Sci. Instr. 76 (2005) 033703.
- 6. C. S. Own, System design and verification of the precession electron diffraction technique, Ph.D. thesis, Northwestern University (2005).
- 7. D. Zhang, D. Grüner, P. Oleynikov, W. Wan, S. Hovmöller, X. Zou, *Precession electron diffraction using a digital sampling method*, Ultramicroscopy 111 (2010) 47–55.
- 8. A. S. Eggeman, T. A. White, P. A. Midgley, *Is precession electron diffraction kinematical? Part II: A practical method to determine the optimum precession angle*, Ultramicroscopy 110 (2010) 771–777.

Diffraction Mapping (DiffMap): A map of diffraction patterns, i.e. a diffraction pattern for a regular array of positions on the sample, may be acquired in two ways (excluding the possibility of numerical nano-beam diffraction from a complex exit face wave function):

- a) sequential sampling of real space by scanning a narrow electron beam across the sample and recording a complete diffraction pattern for each beam position, or
- b) sequential sampling of reciprocal space by using a small objective aperture and recording a series of dark-field (DF) and bright-field (BF) images.

The first option may offer very high reciprocal-space resolution but may result in very long acquisition times, if a large number of real-space points are desired. The second option has generally a rather poor reciprocal-space resolution (determined by the size of the objective aperture) but, because of the parallel acquisition, perfect registration in real space, at least for a single diffraction vector, is achieved. In many cases, also the real-space resolution obtainable by the latter approach is superior to the one obtained by scanning the beam on the sample in the first approach recording individual diffraction patterns. This feature was also taken advantage of in the very interesting application presented in Ref. 5 below.

The QED plug-in facilitates the second approach, including the possibility to define different exposure times for BF and DF images, thus increasing the dynamic range of the reconstructed diffraction patterns and allowing the central beam to be included with the patterns. Because the acquisition of diffraction maps for a large number of reciprocal-space sampling points may take a significant amount of time (20 min up to more than 1 hour), the QED plug-in also provides automated on-the-fly drift compensation. This drift-compensation is achieved by regularly acquiring BF images, measuring the relative drift between successive BF images and controlling the image-shift coils of the microscope to compensate for the measured specimen drift. Because it is based on the BF images of unchanged contrast this approach is very reliable.

Furthermore, compensating any specimen drift via the image-shift coils has the additional advantage that it preserves the full field of view.

- 1. D. J. Dingley and M. M. Nowell, *The use of electron backscatter diffraction for the investigation of nano crystalline materials and the move towards orientation imaging in the TEM*. Michrochim. Acta 147 (2004) 157–165.
- 2. D. Dingley, *Method and apparatus for determining crystallographic characteristics*, US Patent No. 5,576,543
- 3. D. J. Dingley, *Orientation Imaging Microscopy for the Transmission Electron Microscope*. Microchim. Acta 155 (2006) 19–22.
- 4. G. Wu and S. Zaefferer, Advances in TEM orientation microscopy by combination of dark-field conical scanning and improved image matching. Ultramiscroscopy 109 (2009) 1317–1325.
- 5. C. Li and D. B. Williams, *A new TEM method of interfacial thin film characterization*. Journal of Electron Microscopy 54 (2005) 57–60.

Fluctuation Electron Microscopy (FEM): Just as for diffraction mapping, it is possible to acquire fluctuation electron microscopy data by either sequential sampling of real space and parallel recording of diffraction in reciprocal space (a large number of diffraction patterns) or sequential sampling of reciprocal space and parallel recording of image in real space (a set of hollow-cone DF-images for a set of different illumination tilt angles). Both approaches have traditionally been implemented (see references below).

The QED plug-in allows FEM data to be recorded as a well-calibrated series of hollow-cone DF images (i.e., the real-space approach). However, as for this software's implementation of PED, each hollow-cone DF image is the sum of a finite series of DF images acquired at discrete beam tilts with the same deflection angle but equally spaced azimuth. The drift compensation available for diffraction mapping is also applicable when acquiring FEM data.

- 1. M. M. J. Treacy and J. M. Gibson, *Variable coherence microscopy: a Rich Source of Structural Information from Disordered Systems* Acta Cryst. A52 (1996) 212
- 2. M. M. J. Treacy, J. M. Gibson, L. Fan, D. J. Paterson and I. McNulty, *Fluctuation microscopy: a probe of medium range order*, Rep. Prog. Phys. 68 (2005) 2899–2944
- 3. M. M. J. Treacy, *Fluctuation microscopy: what it is?*, Microscopy Today 13(5) (2005) 20-21
- 4. S. N.Bogle, L. N.Nittala, R. D. Twesten, P. M. Voyles, J. R. Abelson, *Size analysis of nanoscale order in amorphous materials by variable-resolution fluctuation electron microscopy*, Ultramicroscopy 110 (2010) 1273–1278

2. Installation:

The installation of the QED plug-in is achieved by simply copying the files 'QED.gtk', 'QEDlib.gt1', 'QED.dll' and 'QEDViewer.dll' to the 'PlugIns' folder within your DM installation (e.g. 'C://Program Files/Gatan/DigitalMicrograph/' for GMS 1.x). If you install QED for GMS 2.x in a 64-bit system you will need to copy the files 'QED64.gtk', 'QEDlib64.gt1', 'QED64.dll' and 'QEDViewer.dll' to the corresponding folder. On a 32-bit system running GMS 2.x the filenames contain '32' instead of '64'. It is also important that the *IPU plug-in* (compatible with your GMS version) is installed as well. After these files have been copied, DM must be restarted for these changes to take effect. Note that if you have already performed QEDtest, you may already have the files 'QEDtest.gt2' and 'QEDlib.gt1' installed. You may keep the file 'QEDtest.gt2' to test or check your system in future.

Please note that QED.dll and QEDViewer.dll will only be loaded by DM, if the USB dongle provided with the QED software is installed at the time DM is started. This DLL is essential for proper functionality of the QED acquisition GUI (see Figure 3) and off-line data reduction using the QED menu.

Note: The driver for the USB dongle should be installed following the instructions of the driver installer.

Revision Records

New features in version 1.4

The new command "Reconstruct CBED pattern" has been added.

New features in version 1.3

The new command "Merge split data" has been added, and a bug relating a split data acquisition has been fixed.

New features in version 1.2

The new illumination calibration using the DF images has been introduced, which simplifies the alignment procedure using the BF images.

New features in version 1.0.1

The plug-ins for GMS 2.0 32bit and 64bit have been released.

3. Getting Started:

Once the plug-ins have been installed, DM's main menu will contain an additional menu item, called 'QED' that has a set of commands shown below.



Figure 2: Menu created in DigitalMicrograph by installing the QED plug-in. In case the QEDtest.gt2 is also installed, the menu item "QED test ..." will appear at the top as well.

Selecting 'QED Acquisition ...' will open the following QED acquisition GUI.

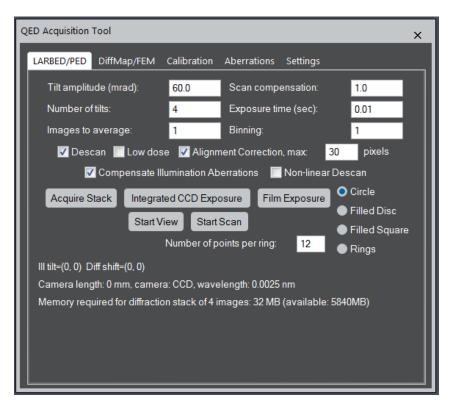


Figure 3: Screen shot of the acquisition tool that opens when starting 'QED Acquisition ...'.

Before acquiring your first LARBED, PED, DiffMap, or FEM data set, it is important to run at least the automated beam-tilt calibration routine. For the acquisition of LARBED or PED data sets, it is also recommended to run the aberration calibration routines as well. These acquisition routines will also work without aberration compensation, but there is no guarantee that all the information you obtain will stem from the same area you illuminate with the beam along the microscope's optic axis.

If you perform a LARBED or PED experiment for the first time, you typically need to follow the following procedure:

- 1. Setup the desired illumination conditions (select spot size and intensity)
- 2. Calibrate Beam Tilt and descan (in DIFF mode section 4.1)
- 3. Calibrate Beam Shift (in IMG mode section 4.3)
- 4. Calibrate the illumination aberrations (in IMG-mode section 5.3 (BF-mode) or section 5.4 (DF-mode))
- 5. Calibrate the Beam Shift-induced Tilt (in DIFF mode section 4.2)
- 6. Start your LARBED or PED experiment (chapter 6)

For this reason, after introducing the automated calibration functions for deflectors, the calibration and measurement of pseudo aberration coefficients will be discussed, before explaining the actual acquisition procedure.

4. Calibration of the deflection systems:

4.1. Diffraction calibration (Tilt and Descan):

When starting the acquisition of LARBED or PED patterns at a camera length for which no calibration has been created yet, a message box (see Figure 4) will appear which reminds the user to first calibrate the beam tilt- and de-scan coils before acquiring diffraction data. Note that these calibrations are also high voltage and camera dependent. On a system featuring more than one CCD camera, QED will require separate calibrations for each detector on which you want to acquire diffraction data. Also when changing the accelerating voltage of the microscope, QED will ask for a separate calibration. All calibration data is stored in DM's global tag structure under 'QED:Calibration:[high voltage]:[camera name]', where the square brackets must be replaced by the actual settings.

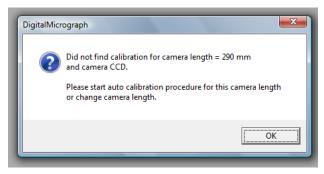


Figure 4: Message box that will appear at an attempt to acquire data if an un-calibrated diffraction setting is encountered.

The diffraction-mode calibration is best done with the sample removed from the field of view. The diffraction pattern will then consist of the undiffracted beam only. Some of the examples shown below have been recorded in this way. The intensity of the diffraction pattern should be adjusted so that it does not severely over-expose the CCD camera. It is important to select the exposure time and binning such that the CCD will not be damaged! This may be verified by running the CCD camera in view mode (make sure to stop the view mode before acquiring your data or starting the calibration!). The same exposure time and binning should then be used as the Exposure time and Binning settings in the Diffraction Calibration box in the Calibration tab (see Figure 5) and the LARBED/PED tab (see Figure 23). Note that changing the exposure time for diffraction data in the Calibration tab also changes it in the LARBED/PED tab and the other way around. The same relation exists between Exposure time and Binning in the Imaging Calibration box and the DiffMap/FEM tab (see Figure 34). The value set for the number of Images to average of the LARBED/PED tab has no effect for the calibration, where it will always be set to 1.

Users who know what they are doing may also specify **Tilt amplitude** in integer DAC units for the calibration. These units are used internally for communicating with the microscope. However, it is suggested to simply leave this value at '0', because in that case the calibration routine will automatically determine a value that corresponds to 1/2 of the available field of view in either direction for any camera length.

The Correlation threshold indicates the smallest acceptable value of the maximum found by the feature-tracking algorithm. If no peak above this threshold can be found, then the calibration will be aborted. Such failure of the calibration routine can occur, if an objective aperture is obstructing the direct beam of the diffraction pattern, or the diffraction pattern has shifted out of the field of view, e.g. by specifying too large a value for **Tilt amplitude (DACs)**.

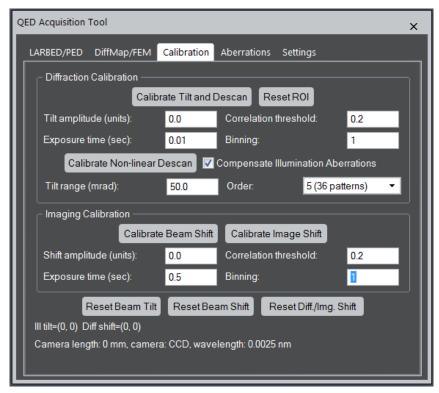


Figure 5: The <u>Calibration tab</u> of the QED Tool. This shows the experimental conditions and buttons relevant for calibrating the beam tilt, tilt de-scan, and beam-shift-induced beam tilt as well as the beam shift and image shift. It also provides a few buttons to reset the illumination tilt and diffraction shift for the unlikely case that this is needed.

The QED calibration relies on DM's calibration of diffraction patterns, i.e. it requires that diffraction patterns are calibrated in the units ' $1/\mu$ m', '1/nm', or '1/A' using a known sample. Only then can the software properly calibrate and apply the illumination tilt.

Pressing the **Calibrate Tilt and Descan** button will launch the fully automated calibration procedure for the beam tilt and the tilt de-scan. This procedure will first produce a continually updating image of the diffraction pattern. The user is then asked to move the central spot of the diffraction pattern well inside the region of interest (ROI) defined in the image. Alternatively, one may also move the ROI to the central spot and/or re-size the ROI. However, one should not move the ROI too far from the image center, because otherwise the calibration routine may shift the diffraction pattern outside the area captured by the CCD. Pressing the **Reset ROI** button will reset the size of the selection to 1/8 of the field of view of the whole detector and position it at the center of the view window. It is then a very simple task to move the diffraction pattern to the center of the detector.

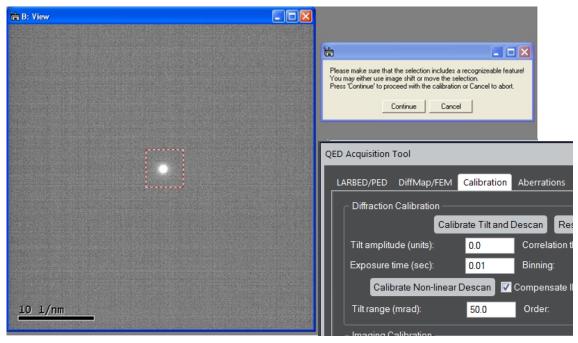


Figure 6: Screen shot demonstrating how the diffraction pattern should be set up for running the automated calibration routine.

Once the user has brought the central beam within the ROI, the actual calibration may be started by pressing the 'Continue' button which should finish with the message 'Calibration successful', as shown in Figure 7.

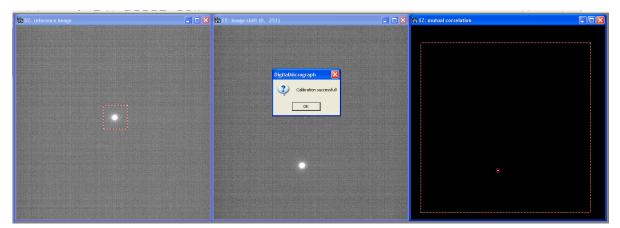


Figure 7: Screen shot of the 3 images shown at the point of completion. The image on the left is the reference image, the image in the center shows the tilted or shifted diffraction pattern, and the one on the far right shows a special correlation function used to measure the relative shift between the two images. Acknowledging the completion of the calibration by pressing 'OK' will automatically close all of these three windows.

The procedure for diffraction calibration is therefore as follows:

1. Setup the TEM in Diffraction mode and select the camera length to be used in an experiment (e.g. about 300 mm to capture also high-order reflections). Make sure the diffraction pattern is calibrated for the selected camera length.

- 2. Converge illumination to spread the intensity of the center beam, and (if the sample is inserted in the beam) remove the sample from the beam.
- 3. Adjust the exposure time according to the dynamic range of a CCD camera by increasing the time, say from 0.01 sec.
- 4. Set the exposure time and binning in the Diffraction Calibration pane of the QED <u>Calibration tab</u>, and press the Calibrate Tilt and Descan button.
- 5. In the view window that then opens, adjust the central spot well inside of the ROI, and press **Continue** button. When finished, the message 'Calibration successful' should appear.

4.2. Diffraction calibration (non-linear Descan):

The diffraction shift calibration procedure described in section 4.1 independently measures the diffraction shift along two deflector systems. If both the beam tilt and the diffraction shift behave in a fully linear manner, this calibration would be sufficient. However, it turns out that, although much smaller deviations from the optic axis are involved, the diffraction shift does not behave in a fully linear fashion on most microscopes. This is shown in the left hand column of Figure 8 (recorded on the Zeiss SESAM for a tilt amplitude of 60 mrad (=3.4°)), an application of a simple linear calibration may result in delocalized scan figures in PED patterns at large precession angles, or in distorted discs in LARBED patterns for large LARBED disc radii. This problem can be overcome by adjusting the Descan calibration applying a non-linear calibration scheme which is based on a larger number of diffraction tilts used for acquiring the actual experimental data (see the illumination aberration compensation described in chapter 5). Applying such non-linear calibration scheme compensates any residual movement (beyond the precision limitations imposed by the remote control interface used by DigitalMicrograph to control the microscope deflection coils) of the diffraction pattern with beam tilt, as demonstrated in the right hand column of Figure 8.

This non-linear de-scan calibration may be performed right after the **Tilt and Descan** calibration. However, it also serves another purpose: On many microscopes the compensation of aberration-induced probe wandering described in chapter 5 also introduces additional beam tilt which may then also distort the scan pattern recorded on the CCD camera. If the **non-linear Descan** calibration is performed with the **Compensate Illumination Aberrations** option turned on *after* the calibration of the illumination pseudo-aberrations, it will also compensate shifts in the diffraction pattern caused by this additional beam-shift-induced beam-tilt. If the **Compensate Illumination Aberrations** option is turned off, then the beam will not be shifted on the sample for compensating illumination aberrations during this calibration. It is strongly recommended to perform this calibration with the same setting of the **Compensate Illumination Aberrations** option as used when acquiring the actual experimental data.

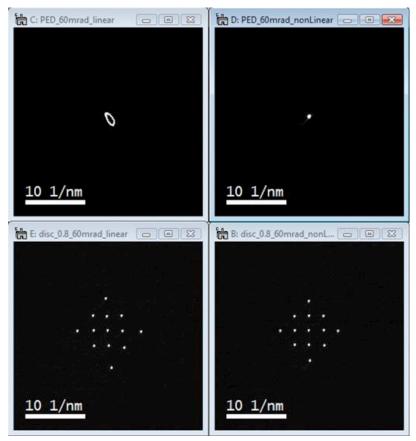


Figure 8: Comparison of PED (top row) and LARBED patterns (bottom row) acquired using a linear (left column) and non-linear (right column) diffraction shift calibration on the Zeiss SESAM. The tilt range was set to 60 mrad in all four patterns.

The experimental setup for calibrating the Shift-induced tilt is identical to the one described in section 4.1. The user then has the choice to either apply this non-linear calibration during data acquisition, or not.

The procedure for calibrating the shift-induced tilt is therefore as follows: Perform this calibration right after the **Tilt and Descan** calibration. It is recommended to perform this calibration with the same setting of **Compensate Illumination Aberrations** option.

- 1. Setup the TEM in the same conditions as used for the diffraction calibration.
- 2. Set the exposure time and binning in the Diffraction Calibration pane of the QED <u>Calibration tab</u>, and press the Calibrate non-linear Descan button. If the Illumination Aberrations have been measured, Compensate Illuminations Aberrations may be turned on.
- 3. In the view window that then opens, adjust the central spot well inside of the ROI, and press **Continue** button. When finished, the message 'Calibration successful' should appear.

4.3. Imaging calibration (Beam Shift):

In order to shift the beam for compensating aberrations of the illumination system, one must first calibrate the amount of shift induced by the beam shift coils. This calibration is done automatically when the **Calibrate Beam Shift** button in the **Calibration** tab is pressed.

The beam shift calibration requires a small field of illumination, say not much more than 1/8, compared to the size of the whole CCD detector (not much bigger than shown in Figure 9). As for the calibration of the beam tilt and tilt de-scan, the spot should also be positioned close to the center of the CCD using either the beam shift or the image shift coils or by moving the condenser aperture. Electron optically, it is in most cases best to keep the electron beam as close as possible to the optic axis. The last option may therefore be the preferred one, assuming that the beam shift and image shift are already at their optimized settings.

Even if the image of the condenser aperture is not completely centered or even the condenser aperture is not inserted, pressing the **Calibrate Beam Shift** button in the **Calibration** tab will provide opportunity to center the illumination spot. Pressing **Continue** in the dialog box that will appear (similar to Figure 6 for the case of the diffraction calibration) will proceed with the calibration, but pressing **Cancel** will abort it. Note that typically a longer exposure time may be selected for calibrations based on the acquisition of images than for diffraction patterns.

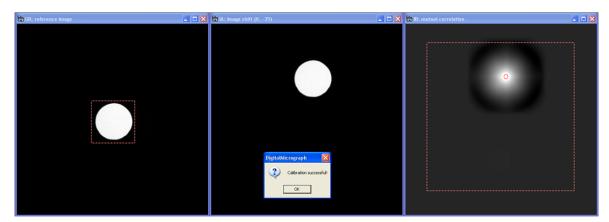


Figure 9: Screen shot of the beam shift calibration wizard at the point of completion. The large square super-imposed on the correlation window shows the valid range within which feature defined by the small selection in the reference image may be located. The little red circle indicates the position of the highest correlation found within this range of validity. Acknowledging the completion of the calibration by pressing 'OK' will automatically close all of these three windows.

The procedure for calibrating the beam shift is therefore as follows:

- 1. Setup the TEM in Image mode, and select the illumination conditions for the magnification at a moderate value, i.e. below about 80 kx (between 10 kx and 30 kx is recommended).
- 2. Setup the illumination probe smaller than 1/8 of the CCD area by using a small condenser aperture or adjusting the magnification accordingly.

- 3. Setup the exposure time and binning in the Image Calibration pane of the QED Calibration tab, and press the Calibrate Beam Shift button.
- 4. In the view window that then opens, adjust the spot well inside of the ROI using either the beam shift or the image shift or by moving the condenser aperture, and then press **Continue** button. When finished, the message 'Calibration successful' should appear.

4.4. Imaging calibration (Image Shift):

The calibration of the image shift works in the same way as the beam shift calibration. It may be run again with a small condenser aperture, or, alternatively, without condenser aperture but a sample with an easily trackable feature positioned at the center of the CCD. The simplest way is probably to just press **Calibrate Image Shift** after completion of the beam shift calibration without changing anything regarding the alignment of the microscope or the sample position.

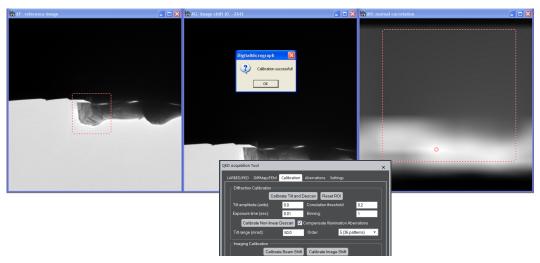


Figure 10: Screen shot of the image shift calibration procedure showing the reference image, the current (shifted) image, and the correlation of the two. The large square super-imposed on the correlation window shows the valid range within which feature defined by the small selection in the reference image may be located. The little red circle indicates the position of the highest correlation found within this range of validity. Acknowledging the completion of the calibration by pressing 'OK' will automatically close all of these three windows.

Note that the image shift calibration is important for measuring the pseudo-aberration coefficients of the microscope in BF mode, but not in DF mode. If the image shift has been calibrated for the current magnification, the aberration measurement will be much more robust because image drift out of the field of view of the detector will be avoided then. For calibrating pseudo-aberrations of the imaging system in BF-mode *a magnification range between 10 kx and 30 kx is recommended*.

Furthermore, the image shift calibration is essential for a prolonged image-mode data acquisition for DiffMap or FEM, where automated on-the-fly drift compensation will be crucial. For acquiring DiffMap or FEM data the image shift must be calibrated *at the same magnification* as used for the data acquisition.

The procedure for calibrating the image shift is therefore as follows:

- 1. Setup the TEM in Image mode, and select the illumination conditions for the magnification at a moderate value, i.e. below about 80 kx (between 10 kx and 30 kx is recommended).
- 2. Setup the illumination probe smaller than 1/8 of the CCD area by using a small condenser aperture, or, alternatively, use a sample with an easily trackable feature positioned at the center of the CCD (see example in Figure 10).
- 3. Setup the exposure time and binning in the Image Calibration pane of the QED <u>Calibration tab</u>, and press the Calibrate Image Shift button.
- 4. In the view window that then opens, adjust the spot or the trackable feature well inside of the ROI, and press **Continue** button. When finished, the message 'Calibration successful' should appear.

5. Correcting Aberrations of the illumination system:

5.1. Background:

Transmission electron microscopes *equipped with an aberration corrector* for the illumination system are ideal for precession electron diffraction, because they allow the electron beam to remain in the same position even at quite large (currently up to about 50 mrad) precession angles¹.

However, this is not the case for a regular TEM without an aberration corrector as illustrated in Figure 11. A positive spherical aberration coefficient of the objective pre-field lens (or the illumination system in general) causes the beam to shift along the direction in which it has been tilted. Diffraction patterns at different tilt angles may therefore originate from very different areas on the sample. Figure 12 gives a more quantitative idea of how far the illuminating beam will move with illumination tilt angle, given specific values for the aberrations.

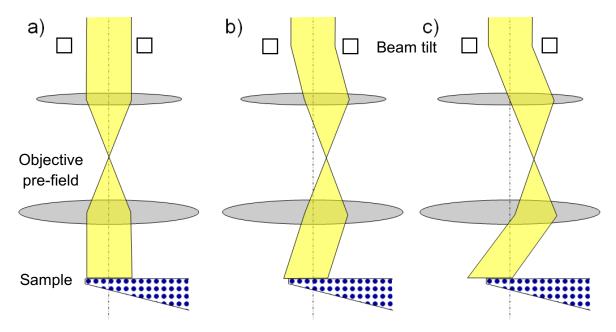


Figure 11: Schematic of the optical path in the illumination system of the TEM: a) untilted illumination b) tilted illumination with $C_s > 0$ for a small tilt angle.. c) tilted illumination with $C_s > 0$ for a large tilt angle. The spherical aberration causes the field of (parallel) illumination to shift proportional to the third power of the deflection angle.

¹ C. S. Own, W. Sinkler, L. D. Marks, *Prospects for aberration corrected electron precession*, Ultramicroscopy **107** (2007) 534542

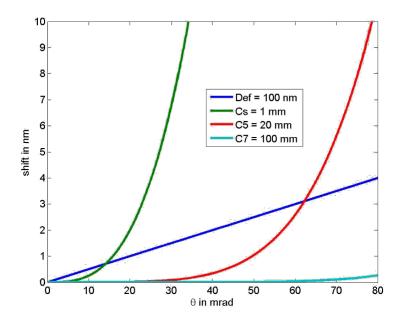


Figure 12: Beam shift induced by various aberrations ($E_0 = 200 \text{ kV}$). While the effect of spherical aberration ($C_s = 1 \text{ mm}$) is already quite severe at tilt angles > 20 mrad, the 5th order spherical aberration ($C_5 = 20 \text{ mm}$) only really matters at tilt angles above 50 mrad. Note that on many TEMs not designed for high resolution work, the aberration coefficients may be much larger than those used in this example.

Since the purpose of the LARBED and PED methods is to obtain diffraction patterns from a very well-defined area on the specimen, it is important to compensate the tilt-induced shift of the illuminated area. This compensation may be done by moving back the beam by using the beam shift. It will be described below how the QED plug-in measures all 42 complex-valued pseudo aberration coefficients of the illumination system in a fully-automated fashion. These coefficients are then used to compensate for tilt-induced beam shift during acquisition. Mathematical details regarding the precise formulation of the pseudo-aberration coefficients and their measurement are described in the literature². Here, we will only give a very short We call these coefficients the imaging and illumination pseudo-aberration coefficients, because they mainly correspond to the aberration coefficients of the objective lens (imaging system) and objective pre-field lens (illumination system), respectively. However, they also include the effect of projector lens distortions and imperfections or nonlinearities in the separation of beam tilt and beam shift. Their magnitude also scales with DM's calibration of the acquired images and diffraction patterns. However, even if DM's scale bars are not correctly calibrated at all, as long as they do not change, the pseudo-aberration coefficients obtained by the QED plug-in remain self-consistent and will keep the probe from wandering about your sample – and this is all that they are meant to be used for.

² C. T. Koch, Aberration-compensated large-angle rocking-beam electron diffraction, Ultramicroscopy **111** (2011) 828-840.

Figure 13 provides an example of a probe shift map produced from a set of illumination pseudo-aberration coefficients measured for the Zeiss SESAM, displayed once as amplitude and angle (top row) and, alternatively, as shift along the two orthogonal directions (bottom row). Applying the probe shift associated with a specific beam tilt (horizontal and vertical axes of the map) will keep the probe always at the same specimen position.

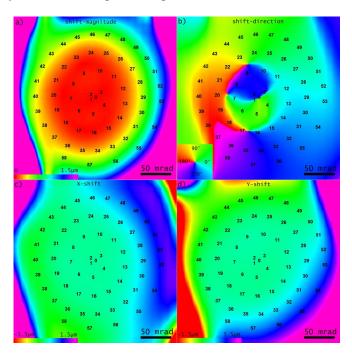


Figure 13: Map of the tilt-induced probe shift on the sample as produced by the QED software, once shown as shift magnitude (a) and direction (b) and, alternatively, as beam shift parallel to the horizontal (c) and vertical (d) axes of the CCD detector. The color scale has been limited to shifts \leq 1.5 μ m. The axes of these maps represent the illumination tilt angle (in mrad, as indicated by the scale bar). The spiral pattern of numbers in each figure indicates the tilt angles of the 59 dark-field images recorded during the automated aberration calibration procedure to determine all 42 complex-valued pseudo aberration coefficients up to 7th order. The first 3 images (numbers 0, 1, and 2) were recorded for equal tilt amplitudes of 5 mrad, differing in their azimuth by 120°.

5.2. Calibration of pseudo-aberrations in **BF-** or **DF-mode**:

The aberration calibration may be done in two ways: a) first calibrating the aberrations of the imaging system and then calibrating the illumination system and b) calibrating the movement of a small illuminated area on the sample by tracking the position of the on-axis dark-field image on the detector. The latter approach requires an amorphous sample with trackable features in order to have a detectable signal at all tilt angles.

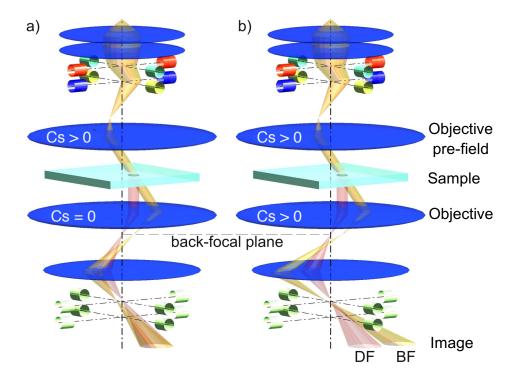


Figure 14: Illustration of the effect of spherical aberration of the objective lens on the measurement of the spot on the sample in the image mode, assuming, for the purpose of illustration, that C_s is the only significant aberration. a) If $C_s = 0$ for the imaging system, both the images of the tilted undiffracted beam (yellow beam) and the diffracted beam (red beam) end up at the same position on the detector. b) In an uncorrected microscope (or if the sample is not perfectly focused) images of the diffracted and undiffracted beams are detected as BF and DF images at different positions on the detector.

As illustrated in Figure 14b, aberrations of the objective lens will induce a tilt-dependent image shift of the illuminating probe, exaggerating its actual movement on the sample. As discussed in detail in², when tracking the movement of the illuminating spot on the detector by recording its bright-field (BF) image, it is necessary to characterize the aberrations of the objective lens, in addition to those of the objective pre-field lens. However, if one brings some amorphous sample area within the field of view, inserts a small objective aperture and aligns it with the microscope's optic axis, the movement of the probe on the sample may be tracked directly by following the movement of the dark-field (DF) image of the probe on the sample, independent of the aberrations of the objective lens. Here, the DF image is created by diffracted electrons that pass through the small objective aperture on the optic axis. Either method has some advantages as well as disadvantages, which is why QED offers a choice of either method (BF or DF). While the BF calibration requires both imaging and illumination aberrations to be calibrated, its advantage is that, once the aberrations of the objective lens (the imaging system) have been determined, the aberration calibration of the illumination system may be performed without any sample. The DF method, on the other hand, may be simpler in that it requires only a single calibration step, but it may involve very long exposure times if the scattering of the amorphous sample is weak.

5.3. Measuring microscope pseudo-aberration coefficients in **BF-mode**:

The calibration of the microscope's aberrations requires that all the relevant calibrations (beam tilt, beam shift and image shift) have been performed beforehand. The aberration calibration in BF-mode is done in at least 2 steps: First the imaging aberrations are calibrated, and then the illumination aberrations can be quantified. This is because the tilt-induced beam shift is introduced by the illumination system as well as the imaging system (objective lens), as illustrated in Figure 14 and Figure 15. If the pivot-point of the illumination system is not properly adjusted, or it behaves in a non-linear fashion (to be expected even on a perfectly aligned TEM if the tilt range is sufficiently large, i.e. greater than 50 mrad), the shifted probe should be moved back by applying some beam shift, which will induce some beam tilt. The user therefore has the option to refine the pseudo-aberration calibration by repeating these 2 steps again (more on the aberration calibration refinement in section 5.3.3).

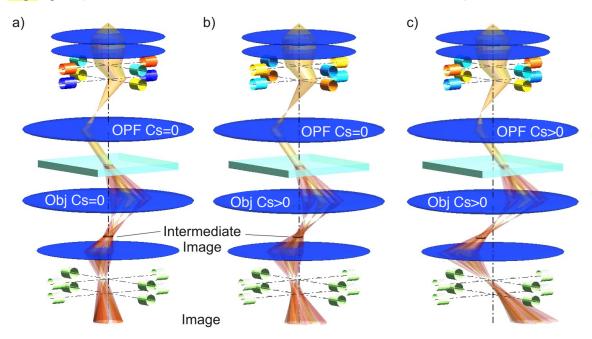


Figure 15: Diagram illustrating the effect of aberrations of both the objective pre-field (OPF) lens as well as the objective lens. a) If the spherical aberration of both lenses is zero, the image as well as the spot on the sample remains well-focused and not displaced, even if the beam is tilted with respect to the optic axis. b) Aberrations of the objective lens have the effect that the intermediate image will shift with beam tilt and also the image on the detector will be shifted and blurred, because the partial image produced by each of the diffracted beams is shifted by a different amount. c) Aberrations of the illumination system will shift the probe on the sample with beam tilt. This shift is amplified by the aberrations of the objective lens so that the apparent movement of the illumination probe in the detector plane is greater than the actual movement of the probe on the sample.

5.3.1 Calibrating aberrations of the imaging system in **BF-mode**

Before starting the measurement of the pseudo-aberration coefficients of the imaging lens system, one should decide on the desired order of aberration compensation. Using a higher aberration order provides higher accuracy because of the larger number of coefficients being fitted but requires more images to be acquired (see Table 1) and thus prolongs the calibration time. Depending on the microscope and size of detector *it is recommended to perform the*

aberration calibration at a moderate magnification, i.e. below about 80 kx, in some cases as low as 10 kx.

Also, for calibrating the image aberrations, the objective lens current should be at its nominal value and the sample should be at the eucentric height. It is important to select such reproducible conditions, since the fitted pseudo-aberration coefficients for the imaging system depend on the alignment of the microscope as well as the position of the sample (especially the defocus). The coefficients fitted at the area of the sample will only be valid at the same area in the field of view, provided that the microscope alignment has not changed in between and the sample is at the same height. Depending on the stability of the microscope and the desired accuracy, however the aberration calibration may then only have to be done once for all future QED sessions.

Similar to the acquisition of diffraction maps, any specimen drift may be compensated for by acquiring a new BF reference image every few frames. The number of tilted images to be acquired between successive BF reference images may be specified in the field '**Reference image every**' in the <u>Aberration tab</u> (e.g. 5 in the example shown in Figure 16). Choosing a small number results in a more robust measurement in the presence of specimen drift but will also slightly prolong the total acquisition time for this calibration procedure.

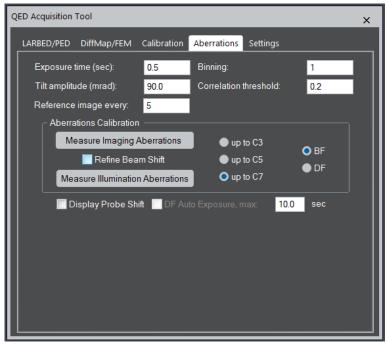


Figure 16: Screen shot of the <u>Aberrations tab</u>. Here the BF mode has been selected and specimen drift will be compensated by acquiring on-axis BF reference images after every 5 images at tilted illumination.

Pressing the **Measure Imaging Aberrations** button in the <u>Aberration tab</u> will start the corresponding automated calibration routine. As for the case of the other calibrations, the software will first pop-up the dialog as shown in Figure 17 asking the selection to be repositioned and adjusted in size to define a trackable area of the sample. Once the **Continue** button has been pressed a series of tilted images will be acquired. The number of images depends on the selected order of pseudo-aberration coefficients to be fitted (i.e. up to C3, C5,

or C7) and is given in Table 1. If the illumination aberrations have not been calibrated yet, the **Refine Beam Shift** checkbox should **not** be selected.

Aberration order	Number of pseudo- aberration coefficients	Number of images required
up to C3	12	20
up to C5	25	36
up to C7	42	57

Table 1: List of the number of pseudo-aberration coefficients being fitted to the tilt-induced imageor beam-shift and the number of images acquired by the calibration routines to determine these coefficients. Note that each of the pseudo-aberration coefficients is complex-valued, i.e. it has an amplitude and a phase.

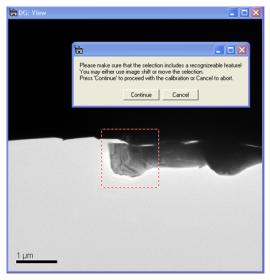


Figure 17: Screen shot showing an example of how a trackable feature may be selected in the View window that opens when the **Measure Imaging Aberrations** button is pressed.

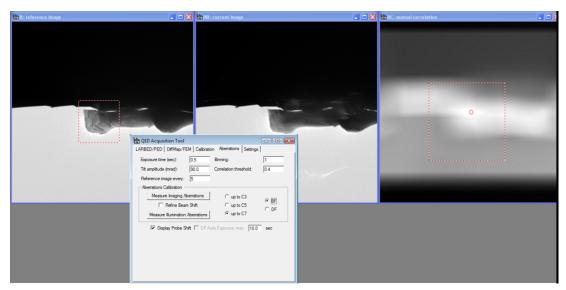


Figure 18: Screen shot of the image aberration calibration module in action. The relative shift between the current image and the reference image is kept small because of the compensation of the image shift according to the dynamically updated pseudo aberration coefficients.

Because the tilt-induced image shift can be quite large (several μm) (see Figure 13), this automated calibration routine will predict the image shift at the next beam tilt and compensate it as much as possible. It does so based on the current estimate of the pseudo-aberration coefficients that have been fitted to the measured image shifts of the images already acquired. As the number of acquired images increases so does the accuracy of these preliminary coefficients and with that the accuracy of the predicted image shift. The calibration routine therefore changes the beam tilt in a spiral pattern, starting with small beam tilts and gradually increasing its magnitude (see Figure 19 for the numerical values of the applied beam tilt). This

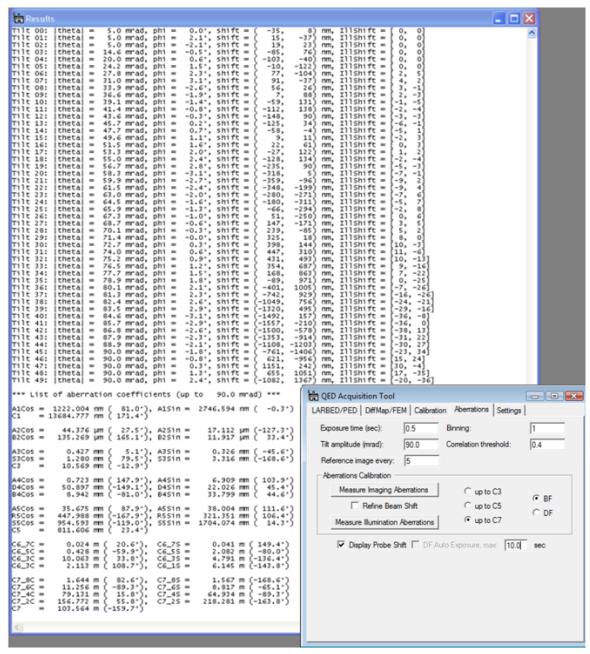


Figure 19: Screen shot of the Results window after the measurement of a set of pseudo-aberration coefficients of the illumination system up to C₇. As each image is acquired, the corresponding tilt angle, measured image shift and applied beam shift (in DAC units) is printed to the results window. Finally, the list of fitted aberration coefficients is also printed to the screen.

procedure ensures that the area of the sample being tracked remains within the field of view of

the detector even for very high values of the pseudo-aberration coefficients (see Figure 18). During calibration the current beam tilt, measured image shift and applied shift compensation will be displayed in the results window (see Figure 19).

The procedure for calibrating aberrations of the imaging system in the BF mode is therefore as follows: (The beam tilt, beam shift and image shift should been calibrated beforehand)

- 1. Setup the TEM in Imaging mode, and select the illumination conditions for the magnification at a moderate value, i.e. below about 80 kx (between 10 kx and 30 kx is recommended).
- 2. Align the objective lens current at its nominal value, and place the sample at the eucentric height.
- 3. Adjust the exposure time and binning, and select the BF-mode and the order of aberrations to be fitted in the QED <u>Aberrations</u> tab.
- 4. Press the Measure Imaging Aberrations button, which opens the View window.
- 5. Adjust the position (and size if necessary) of the ROI and a recognizable feature by moving the ROI or shifting the image, and then press **Continue**.

5.3.2 Calibrating aberrations of the illumination system in **BF-mode**

Once the pseudo-aberration coefficients of the imaging system have been obtained, the aberrations of the illumination system may be calibrated in the very same manner, except that the specimen should be moved out from the field of view and a small condenser aperture should be inserted. The remaining procedure is exactly the same as for calibrating the aberrations of the imaging system. For measuring the aberrations of the illumination system, it is also important to have calibrated the beam shift, in addition to the image shift. If the **Display Probe Shift** option has been turned on the progress of the illumination aberration calibration is displayed graphically as shown in Figure 13. Once this step is completed, QED will print a list of the final pseudo-aberration coefficients as shown in Figure 19 and, we are, in principle, ready to acquire high-quality LARBED or PED patterns.

The procedure for calibrating aberrations of the illumination system in the BF mode is therefore as follows: (The beam tilt, beam shift and image shift should been calibrated beforehand)

- 1. Setup the TEM in Imaging mode, and select the same the illumination conditions and the magnification used for the imaging system calibration.
- 2. Move out the specimen from the field of view, and insert a small condenser aperture.
- 3. Adjust the exposure time and binning, and select the BF-mode and the order of aberrations to be fitted in the QED **Aberrations** tab.
- 4. Press the Measure Illumination Aberrations button, which opens the View window.

5. Adjust the position (and size if necessary) of the ROI and a recognizable feature by moving the ROI or shifting the image, and then press **Continue**. If the **Display Probe Shift** option has been turned on the progress of the illumination aberration calibration is displayed graphically

5.3.3 Refining the aberration calibration in **BF-mode**

Depending on the tilt range being used and the degree of linearity of the electron optics of the microscope the steps described in sections **5.3.1** and **5.3.2** may be repeated, but with the 'Refine Beam Shift' checkbox selected as shown in Figure 21. This setting will use the already existing set of pseudo-aberration coefficients of the illumination system to predict the beam shift necessary to keep the probe from moving on the sample while measuring the tilt-induced image shift (you must press the Measure Imaging Aberrations button to perform this measurement again). Since shifting the beam may also affect the beam tilt, the image-shift response may be slightly better than when this calibration was done for the first time, i.e. without compensation of the illumination aberrations.



Figure 20: Screen shot of the <u>Aberrations tab</u> with 'Refine Beam Shift' turned on. This setting will apply the beam shift necessary to keep the illumination in the same position (as determined from the already existing set of pseudo-aberration coefficients) when measuring the tilt-induced image shift.

One may test the effect of the aberration compensation by acquiring a tilt series of images. Such a tilt series of images may be acquired from within the **DiffMap/FEM** tab (see Chapter 7). The example shown in Figure 21 demonstrates the great improvement in beam position caused by the dynamic aberration compensation. In fact, much of the change in Figure 21b with tilt angle is due to the fact that these images are slightly different 2D projections of a 3-dimensional sample. If the result is still not satisfactory, the aberration calibration may also be refined further by repeating the procedure described in this section again. One should keep in

mind though that, depending on the microscope, the precision with which the beam shift is being compensated may also be limited by the coarseness of the DAC that DigitalMicrograph may control. On Zeiss Libra TEMs, for example, remote control of the beam shift via the RS232 connection allows it to be changed in increments larger than about 20 nm., but on JEOL and FEI microscopes these increments are much smaller.

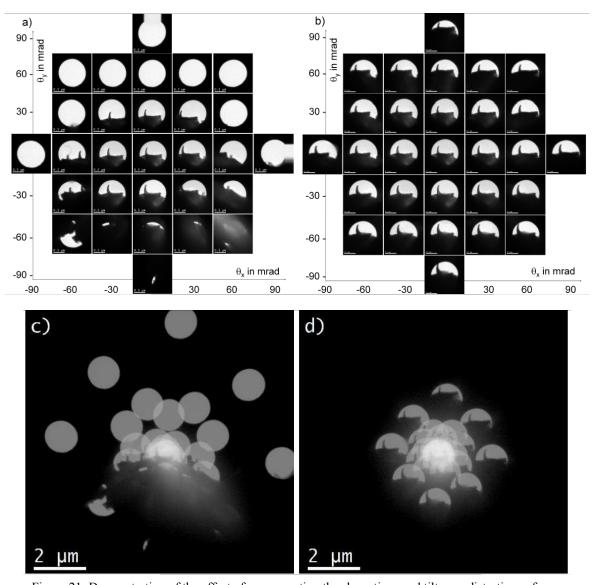


Figure 21: Demonstration of the effect of compensating the aberrations and tilt scan distortions of the illumination system. Images have been recorded for different illumination tilt angles, up to an amplitude of 90 mrad on a square 30 mrad grid. In the top row the areas that are illuminated by the electron beam at the different tilt angles are shown. Here only the portion of the image containing the illuminated area is shown. In the bottom row the sum of all 28 full-sized images is shown (on a log scale). a) and c) The aberration-induced beam shift has not been compensated for. b) and d) The aberration-induced beam shift has been compensated. Note that in d), because the imaging aberrations are not compensated the image still moves although the probe remains almost stationary on the sample. The origin of this effect is illustrated in Figure 15. The length of the scale bars in a) and b) is 500 nm. The accelerating voltage was 120 kV (Zeiss EM912).

5.4 Measuring pseudo-aberration coefficients of the illumination system in **DF-mode**

As illustrated in Figure 14 the electrons (in the red beam), which travel down the optic axis of the microscope and intersect the objective back-focal plane at its center, are not affected by any aberrations of the imaging system (by definition of the optic axis within isoplanatic approximation). Using only such electrons therefore allows the aberrations of the illumination system to be measured directly, no matter how strong the aberrations of the imaging system are.

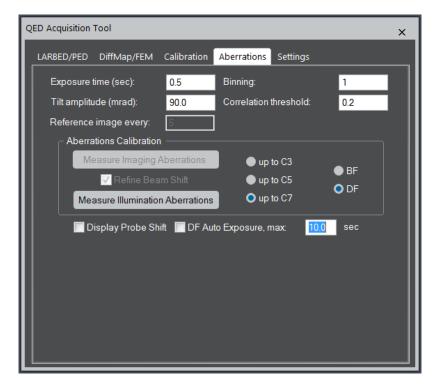


Figure 22: Screen shot of the <u>Aberrations tab</u> set up for a calibration of the pseudo-aberrations of the illumination system in **DF-mode**. Options which are only relevant to aberration calibration in BF-mode are made inactive.

As shown in Figure 22 a number of functions described in sections 5.3.1 – 5.3.3 are not needed anymore in **DF-mode**: It is not necessary to measure the aberrations of the imaging system, nor is it necessary to compensate any specimen drift. However, since we only want to detect electrons which have travelled along the optic axis of the microscope a **small objective aperture** is needed. Also, this calibration is best performed using an **amorphous specimen**, because amorphous structures are expected to scatter in all directions more or less homogeneously no matter how tilted the illumination may be. However, because the scattering of an amorphous sample along the optic axis may become very weak when tilting the beam to large angles, it may be necessary to adjust the exposure time for acquiring DF images. This adjustment is done automatically by QED if the **DF Auto Exposure** option is turned on. The **maximum exposure time** that may be used by QED however must then be specified as well (e.g. 20 seconds as shown in Figure 22). Note that, in order to perform the calibration as precisely as possible, QED will acquire two DF images at each beam tilt. It is important to keep this in mind when estimating the time this calibration procedure may possibly take.

The procedure for calibrating the illumination aberrations in DF mode is therefore as follows:

- 1. Setup the TEM in Imaging mode, and select the illumination conditions to the intensity and spot size desired for the actual LARBED or PED experiment.
- 2. Align the illumination tilt with the microscope's optic axis (rotation center)
- 3. Insert a small objective aperture and switch the microscope back to image mode
- 4. Adjust the exposure time and binning in the QED <u>Aberrations</u> tab to suit the intensity of the BF image, select the maximum exposure time for the auto exposure and press the **Measure Illumination Aberrations** button. It may be necessary to select a rather high binning, and a rather low magnification (10kx 20 kx) in order to increase image counts at large beam tilts.
- 5. In the view window which then opens (similar to the screen shot shown in Figure 6, but for the spot recorded in Image mode), adjust the position (and size if necessary) of the ROI to contain the complete illuminated area and press **Continue**.
- 6. Watch the automated illumination calibration procedure. If you find that the algorithm cannot track the DF image of the illumination anymore (e.g. because the image counts are too few) you may stop the calibration procedure, adjust the experimental parameters (see hints given at step 4) and restart the calibration procedure. If the **Display Probe Shift** option has been selected a window showing the current estimate of the tilt-induced probe shift will appear after DF images for the first 5 tilt angles have been recorded.

6. Acquiring LARBED, PED, or LARCBED patterns:

6.1. Acquiring integrated diffraction patterns

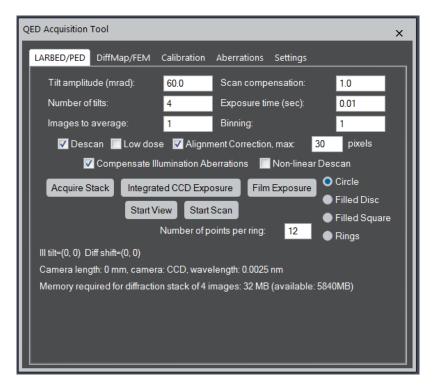


Figure 23: Screen shot of the <u>LARBED/PED</u> acquisition tab of the **QED** Acquisition Tool. It gives access to all the necessary experimental parameters affecting the Acquisition of LARBED and PED patterns.

Once the calibration is completed, the precession can be started and, if desired, viewed on the viewing screen by pressing **Start Scan** in the **LARBED/PED** tab (Figure 23). One may also acquire a single scan (ring, disc, or square) on the CCD detector by pressing **Integrated CCD Exposure**. Without a specimen in the path of the beam this may result in patterns as those shown in Figure 24 and Figure 25.

The acquisition of LARBED patterns may be interrupted at any time by pressing Stop Scan (the same button that was used to start the acquisition).

The user may select between the 3 different shapes shown in Figure 24: a circle comprised of N points, where N is the value specified as **Number of tilts**, a disc comprised of approximately πN^2 points (here the **Number of tilts** specifies the radius of the disc) or a square consisting of $(2N+1)^2$ points. Unchecking the **Descan** box or setting **Scan compensation** to 0 will turn the de-scan off.

The 4th selection is a ring pattern of **Number of rings** concentric rings. This scan shape may be useful if PED patterns for multiple precession angles at equal increments are to be recorded automatically. A non-precessed pattern will then be acquired as well.

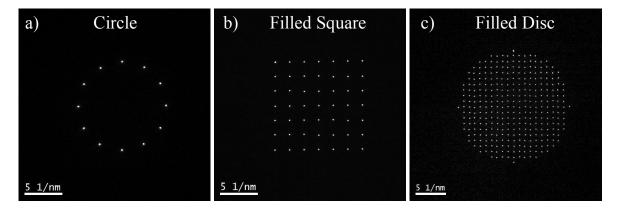


Figure 24: Example of the 3 different shapes for the illumination tilt scan recorded on the Zeiss SESAM 200 kV FEG-TEM: a) circle (here with 12 points and a camera length of 360 mm) b) square (here with the number of points set to 3, resulting in a total of $(2*3+1)^2 = 49$ different beam tilts), and c) disc (here with a radius of 10 points). **Descan** and **Alignment Correction** were turned off in all 3 cases. The data has been acquired with the sample removed from the beam so that only the undiffracted beam was detected.

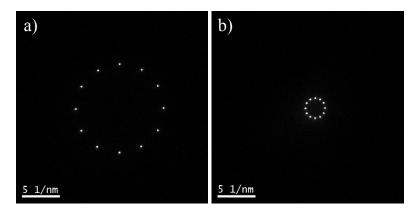


Figure 25: The same ring pattern of the undiffracted beam (sample was removed), recorded a) without any scan compensation and b) with a scan compensation of 0.8(5 times reduced in size). The camera length was set to 360 mm in both cases.

Figure 25 shows the effect of changing the value of the **Scan compensation** from 0 to 0.8. You may note that the size reduction factor is given by 1/(1 - scan compensation factor). Setting **Scan compensation** to 1 will result in a classical precession electron diffraction (PED) pattern. Figure 26 is a more practical example obtained with the scan compensation=0.84.

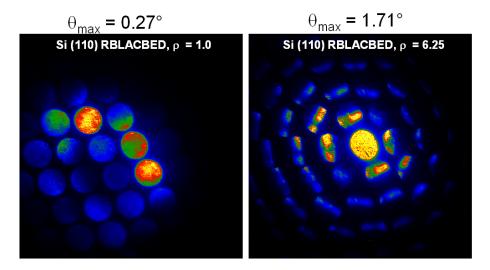


Figure 26: LARBED patterns of a very thin Si (110) sample produced by the software described here. The LARBED pattern shown on the left covers the same tilt range as a conventional CBED pattern (emulating a convergence angle = 0.27°). Increasing the convergence angle in conventional CBED would cause the discs to overlap and disc-specific information would be impossible to extract. The right pattern shows diffraction data for the same position on the Si crystal, but with a 6.25 times larger effective convergence angle. The discs do not overlap here, because of the sequential acquisition and finely tuned de-scan provided by the QED plug-in (scan compensation=0.84, producing discs that are 6.25 times smaller than the tilt range they represent).

Figure 27 demonstrates the very different length scales within and between diffraction discs that results from the very flexible choice of the **Scan compensation** parameter.

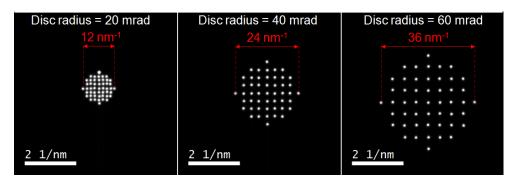


Figure 27: Disc scans acquired with the **Scan compensation** fixed at a value of 0.9 but different tilt amplitudes. Note the very different scales of the diffraction pattern (CCD calibration as indicated by the scale bar at the bottom left of each figure) and the disc diameter (as indicated above each disc). A scan compensation of 0.9 means that the discs have been reduced in size by a factor of 10.

6.2. Acquiring 3D data stacks:

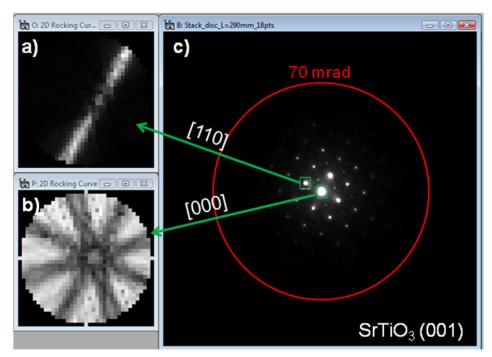


Figure 28: Example 3D data stack. a) and b) extracted diffraction discs. c) one of the frames of the 3D data stack comprising 1009 diffraction patterns (disc with 18 pixel radius). The red circle in c) indicates the range of tilt angles represented by the diffraction discs. The total acquisition time for this data stack was 23 min.

Much of the data reduction functionality provided in the QED menu are designed to extract diffraction information from 3-dimensional data stacks (see, for example, Figure 28). LARBED and PED 3D data stacks consist of individual diffraction patterns recorded at each incident beam tilt and may be acquired using the **Acquire Stack** button. This button works the same as the **Integrated CCD Exposure** button with the difference that in addition to the integrated diffraction pattern a data stack consisting of the individual patterns will be recorded.

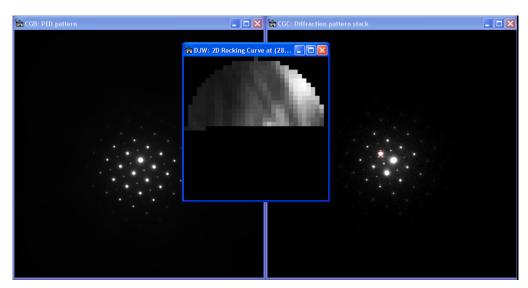


Figure 29: Watching the progress of the data acquisition by live extraction of rocking curves. During acquisition of a data stack two patterns are displayed: the integrated pattern on the left and

the data stack showing the current frame on the right. Since the acquisition runs as a background thread, it is also possible to extract rocking curve information from the data stack during acquisition.

It is possible to start analyzing the data on-the-fly while the acquisition is progressing (see Figure 29). Although the progress is displayed numerically also at the bottom of the **LARBED/PED** tab, the **Display Rocking Curve** command from the QED menu will provide a graphical idea of how far the acquisition has progressed by showing a plot of the 1D or 2D rocking curve of a selected diffraction (Note: you must move or resize the selected area in order to update the rocking curve display.)

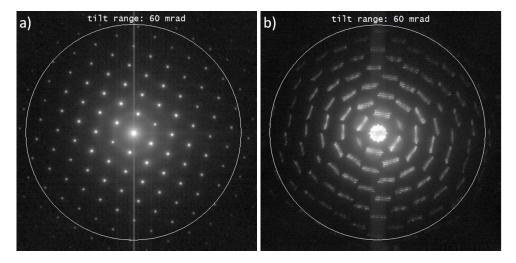


Figure 30: Comparison of two LARBED patterns of thin Si (110). a) pattern recorded with complete de-scan, b) pattern with only partial de-scan, both recorded on a Zeiss EM912 operating at 120 kV. The tilt range was 60 mrad in both cases (indicated by large circle). The aberration compensation was turned on for the acquisition of this data, so that all diffraction points stem from the same specimen position.

Figure 30 demonstrates another advantage of the acquisition of 3D data stacks. The data may then be projected in many different ways to produce either PED-like patterns (Figure 30a) or LARBED patterns (Figure 30b) which contain all the information from the 3D data stack in a 2D pattern.

6.3. Using the on-the-fly Alignment Correction:

During the simple tilt and descan calibration routine the software determines the direction and scale of the illumination tilt, and how much the diffraction patterns need to be shifted to compensate this tilt. Since this calibration assumes a linear behavior of the coils the actual pattern may look quite different, as can be seen in Figure 31, especially at large tilt angles.

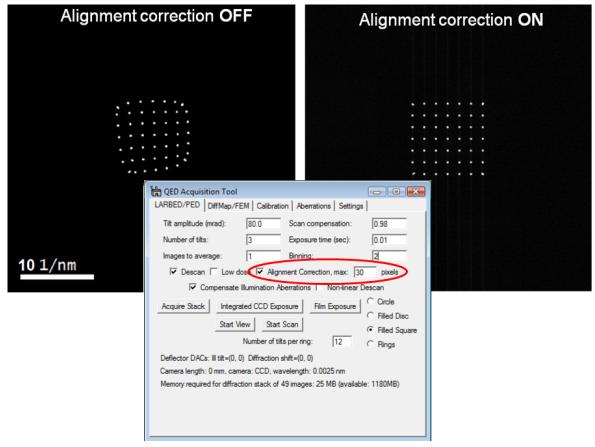


Figure 31: Effect of on-the-fly alignment correction: left: **Alignment Correction** was turned off, right: the **Alignment Correction** was turned on. Acquired on a Zeiss EM912 at 120 kV with a tilt range of ± 80 mrad in both x- and y-direction (note the distorted diffraction spots in the corners, where the beam tilt is 113 mrad).

As an alternative to applying the **Non-linear Descan** option, turning the **Alignment correction** "on" (highlighted in Figure 31) will make sure that the center of the diffraction pattern appears in the final LARBED or PED pattern or data stack at the proper position. This alignment is achieved by tracking the position of the central beam of the diffraction pattern. When the **Alignment correction** is turned "on", the user is therefore asked to identify the central beam in an untilted diffraction pattern, which is acquired just before the actual LARBED or PED scan (see Figure 32).

The value next to **Alignment Correction** specifies the maximum number of pixels that the central beam drift is tracked for. If the beam drifts further than this, the correction will be aborted. One can, for example, estimate a proper value by testing this procedure without Alignment Correction and measuring the *uncompensated* maximum shift of diffraction patterns at high tilt amplitude (see Figure 33). Usually a value between 10 and 50 pixels should suffice

(see also the **Align Stack** function below). Setting this value too high may cause the central beam to be aligned with one of the diffracted beams (especially in thick samples).

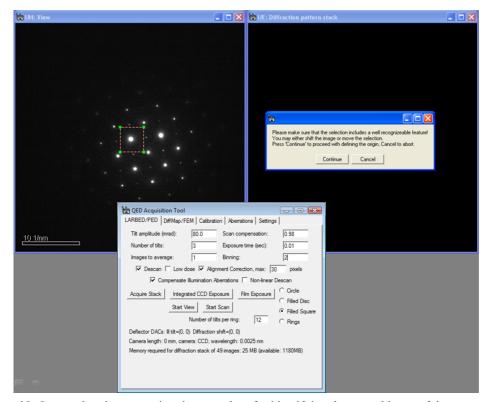


Figure 32: Screen shot demonstrating the procedure for identifying the central beam of the diffraction pattern. This procedure must be followed every time an acquisition is started for which **Alignment Correction** has been turned on. The alignment selection ROI will appear where it had been the last time. It may also be brought back to the center of the diffraction pattern by pressing the **Reset ROI** button in the **Calibration** tab. The diffraction pattern will be updated continuously, using the exposure time specified as **Exposure time**. It is therefore possible either to use the diffraction shift to bring the central beam into the selection ROI or to move (and re-size) the selection ROI to the position of the central beam.

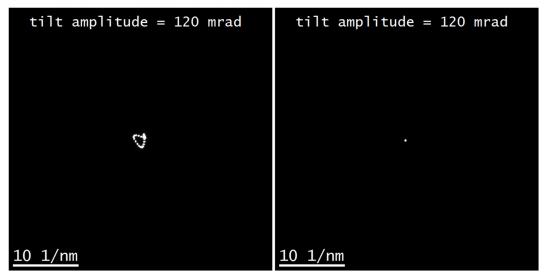


Figure 33: PED patterns recorded by the QED Plug-In on a Zeiss EM912 with a tilt amplitude of 120 mrad demonstrating the effect of the QED alignment correction. The left PED pattern has been recorded without alignment correction, and the one on the right with the **Alignment Correction** turned on.

<u>6.4. Acquisition in spot mode</u>: Large-angle rocking convergent beam electron diffraction (LARCBED)

The examples shown above show data acquired in nanobeam diffraction mode, i.e. with a nearly parallel beam illuminating the specimen. For small unit cell specimen it is certainly also possible to use a convergent illumination and still avoid disc overlap.

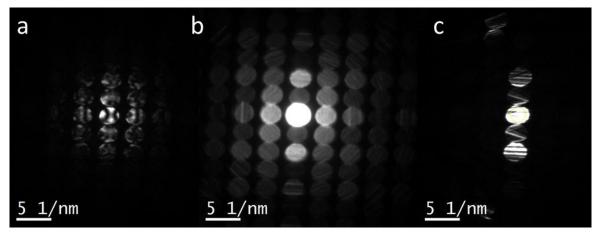


Figure 34: CBED patterns of SrTiO₃ acquired using QED installed on a Zeiss EM912. a) [-110] zone axis pattern, b) sum of all patterns acquired in this experiment (data stack comprised of 709 individual 512 x 512 pixel frames with a maximum tilt range of 60 mrad), and c) one of the CBED patterns acquired at high beam tilt. Aberrations of the illumination system have been compensated up to 5th order. The data has been acquired as a split stack and has been merged afterwards.

It is suggested that before data acquisition the normal alignment procedure is followed, but that the illumination aberrations are measured in the (convergent) illumination mode that will also be used for acquiring the actual data, to make sure that the change in illumination setting has no effect on the quality of the alignment during data acquisition.

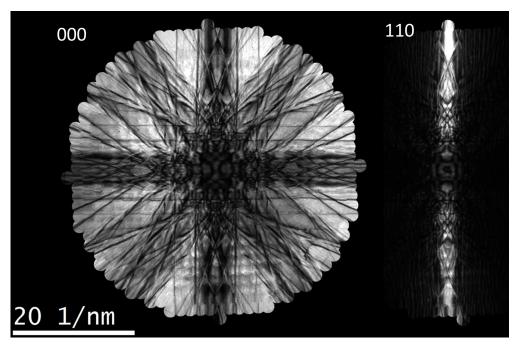


Figure 35: Bright-field (BF) and dark-field (DF) LACBED discs extracted from the data stack shown in Figure 34. Similar data can be extracted from any of the more than 70 reflections shown in Figure 34b.

7. Acquiring Drift Corrected Diffraction Maps and Fluctuation Microscopy data sets:

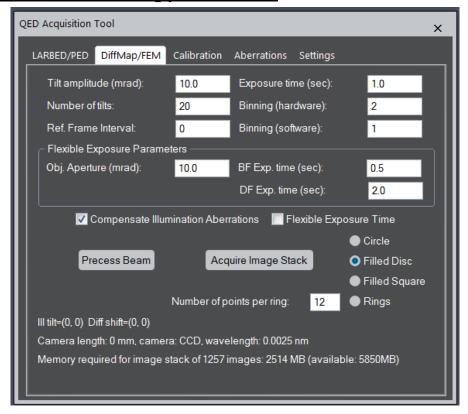


Figure 36: Screen shot of the <u>DiffMap/FEM tab</u>. In this example it is configured for a standard FEM acquisition, using the 'Rings' scan pattern.

Figure 36 shows the <u>DiffMap/FEM</u> tab of the QED Acquisition Tool. The control elements are very similar to those for the acquisition of diffraction data (LARBED/PED). The exposure time for images may generally be chosen much longer than for diffraction patterns, so these are two separate sets of parameters. Also, because dark-field images may have very few counts, the possibility of further binning of images by software is provided. While the maximum hardware binning is restricted by the CCD camera (some cameras allow a maximum binning of 4) there is no limit for software binning.

Because DF images can be quite low in intensity, acquisition times for such diffraction maps may be rather long, and the sample drift may be a limiting factor. However, by applying the on-the-fly drift correction provided by this DiffMap/FEM module, the sample can be kept within the field of view of the detector for many hours. The relevant parameter for drift correction is **Ref. Frame Interval**. It specifies after how many images it should acquire another reference image for compensating for specimen drift. Since DF images may change very much in contrast and certainly differ in contrast from BF images, reference images are always BF images recorded with the beam aligned along the optic axis. Once the drift between successive images has been determined and exceeds 10 pixels, the drift is compensated by sending the appropriate commands to the image shift coils. Image shifts of less than 10 pixels are compensated for by shifting the recorded image during the data reduction step.

The **Rings** scan pattern in the <u>DiffMap/FEM</u> tab (see Figure 36) was included with fluctuation electron microscopy (FEM) in mind. Recording a 3D data stack in this mode will result in a series of hollow-cone DF images with an equidistantly increasing precession angle. It is then just a matter of plotting the normalized variance of these images (or a selection thereof) to obtain the data necessary to perform a FEM analysis. The number of tilts per ring is specified, as usual by the **Number of tilts**. The **Number of rings** specifies the number of different tilt angles per ring, starting with θ =0 and finishing with θ = **Tilt amplitude**. Note that for FEM applications a rather small **Number of tilts** may be sufficient, since, at least ideally, amorphous structures scatter almost isotropically in all directions.

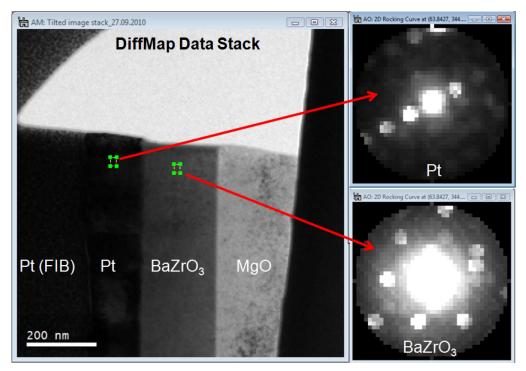


Figure 37: Example of a diffraction map of a multilayer sample. Moving or changing the size of the small ROI will automatically update the content of the locally extracted diffraction patterns.

Figure 37 provides an example of a diffraction map recorded in real space. The automatic adjustment of the exposure time depending on whether the beam tilt is smaller or larger than the radius of the objective aperture allows BF images (beam tilt equal or smaller than radius of objective aperture) and DF images (beam tilt larger than objective aperture radius) to be acquired in the same data stack. Note that also for the drift correction BF images with a potentially different exposure time than the DF images are acquired. Using the **Display Rocking Curve** function from the **QED** menu automatically compensates for differences in exposure time, so that diffraction patterns look as they would if acquired directly (without beam stop). The intensity of diffraction spots my therefore be measured on an absolute scale.

8. Some Basic Data Processing Functions:

8.1. Post-acquisition alignment (Align Stack):

Because of imperfect electron optics and a discretized control of the deflection coils, it is close to impossible to produce a perfect alignment of the diffraction patterns purely by commands sent to the microscope. This becomes quite obvious if looking at stacks of diffraction patterns recorded with full de-scan (i.e. 'Scan compensation' set to 1). Moving through the slices of the data stack, one will notice the diffraction pattern moving slightly. This misalignment can easily be corrected by choosing the menu item 'Align Stack'. The 'Align Stack' function will first ask you to select an area that includes mostly the central beam of the diffraction pattern. This area should be chosen large enough to include the central beam in all slices of the stack. Once the "Continue" button is pressed the routine will align all diffraction patterns based on the content of this selection only.

It is important that the central beam is chosen, because all other diffracted beams may vary largely with incident beam tilt angle. This invariance of the intensity of the central beam with illumination tilt may also be used as a criterion to identify which of the beams is the undiffracted one. Turning 'Auto Survey' of the stacked image off in the Image Display Info Dialog (from Display -> Image Info...) and moving through the slices of the stack will show this very quickly.

In order to prevent the alignment routine to accidentally shift one of the diffracted beam to the position of the central beam, a (default) maximum allowed shift of 10 pixels is defined. This value may be changed by running the 'Align Stack' function with the "Alt"-key pressed. Once this value has been changed, it will be used for all future alignments on that machine.

If the maximum shift has been set to too small a value, the diffraction patterns may not be completely aligned. The alignment can then be repeated once again (or several times).

Since the data alignment routine uses the position of the central beam as a reference, it also sets the origin of the diffraction pattern. It is then not necessary anymore to call the '**Define Origin**' function (see below) for the same diffraction pattern.

8.2. Undoing the stack alignment (**Undo Stack Alignment**):

Working with large data stacks it is very important to waist as little memory as possible. The stack alignment is therefore performed on the original data set. However, since the amount of shift is stored in the tags of the data stack, the original image positions can always be recovered. This can be done by simply pressing the 'Undo Stack Alignment' menu item. The 'Undo Stack Alignment' command will also reset the shift stored in the image tags. Pressing this button more than once will therefore not have any effect on the data.

Note that this function will also remove the diffraction pattern shift applied during acquisition, if it has been recorded with the 'Alignment Correction' option turned on.

8.3. Defining the center of the diffraction pattern (**Define Origin**):

The '**Define Origin**' command asks the user to select an area that only includes the central beam. It assumes that the data is relatively well aligned, and chooses the maximum of a smoothed average of all diffraction patterns (only the area selected by the user) as the center of the diffraction pattern.

8.4 Extract rocking curves of individual reflections (**Display Rocking Curve**):

The command **Display Rocking Curve** extracts 1D tilt scans or 2D rocking curves from data stacks. The rocking curves will automatically update with repositioning or resizing the region of interest.

In Figure 38 and Figure 39 you will find two examples of how this function works. Since all the acquisition parameters are stored within the tags of the image, the **Display Rocking Curve** command automatically decides whether to produce a line plot (circular precession scan) or a 2D rocking curve. As can be seen from Figure 38, the LARBED method allows simultaneous acquisition of LACBED patterns for all reflections, even for materials featuring large unit cells. Also, if used in nano-beam diffraction mode and with aberration compensation turned on, the illuminated area movement may be orders of magnitude smaller than in conventional LACBED.

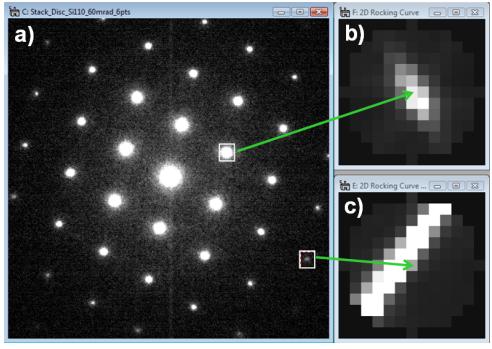


Figure 38: Extraction of LACBED discs from a LARBED data stack of Si (110) recorded using the 'Filled Disc' shape. a) Diffraction pattern corresponding to the central pixel of the extracted LACBED discs, as pointed to by the arrow heads in two extracted discs b) and c). The maximum tilt angle in these scans was set to 60 mrad. The accelerating voltage was 120 kV (Zeiss EM912). The intensity within the ROI (in this case, $23 \times 26 \text{ pixels}$) was integrated in each diffraction pattern. The grey scale of the LACBED discs was set to b) -5000 ... 65900 counts (max. integrated intensity = 65998) and c) -1000 ... 14200 counts (max. integrated intensity = 26995). The data has been recorded with the aberration compensation turned on.

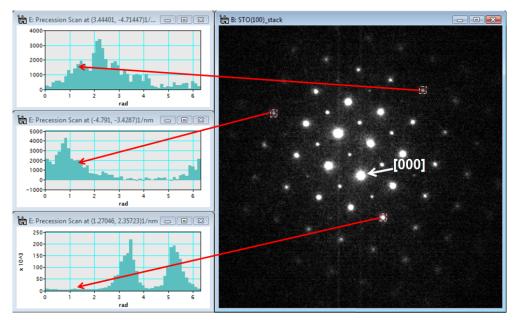


Figure 39: Example of the extraction of precession profiles from a LARBED stack acquired using a circular tilt scan from $SrTiO_3$ aligned near its (100) zone axis . The profile will be updated continually as the ROI is dragged around.

8.5 Produce table of diffraction intensities (**Print Rocking Curve**):

Calling the '**Print Rocking Curve**' command will print a list of the integrated intensity within the selected ROI to the Results window in the form of a table.

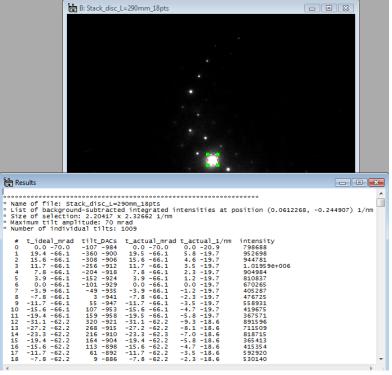


Figure 40: Example of a list of integrated intensities extracted from a LARBED stack printed to the Results window. The generated table can then be saved or copied to another number processing software. The different columns contain the intended ('ideal') beam tilt in mrad, the DAC units sent to the microscope and the actual tilt angle in both mrad and 1/nm. The final column contains the integrated intensity (background subtracted in the case of diffraction patterns).

8.6. Projections of PED/LARBED data (Integrate Stack):

Having a set of all the diffraction patterns available, it is certainly easy to integrate over the different incident beam tilt angles by projecting the data stack along its depth, resulting in a single integrated diffraction pattern. This is simply done by pressing the 'Integrate Stack' menu item. If the data stack has not previously been aligned, a warning will appear. However, this warning can also be ignored if that is what the user wants. Note that the small shifts induced by the alignment routine will also average over some of the noise introduced by correcting for the dark current. In some cases this may greatly improve the S/N properties of the PED patterns.

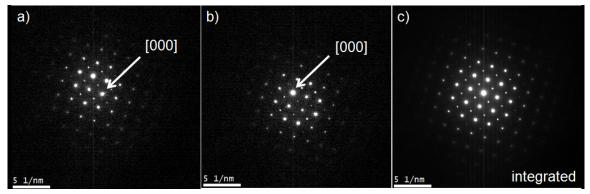


Figure 41 Diffraction patterns of SrTiO₃ (100): a) and b) two different patterns extracted from the LARBED stack. Note that the undiffracted beam is not always easily identifiable. c) Integrated diffraction pattern corresponding to a conventional PED pattern. This pattern is much more symmetric and also much less noisy than those shown in a) and b). Recorded on a Zeiss EM912, not energy-filtered.

8.7. Different projections of LARBED data (**Reconstruct LARBED Pattern**):

Integrating a data stack is only one of many possible projections. For this stack integration the patterns are summed up in the same position as they are present in the stack. Many more projections are possible, if the patterns are shifted before being summed. In this section we will show useful examples where this shift is proportional to the illumination tilt, with which each frame of a LARBED data stack has been recorded. Figure 42 shows an example of 6 different projections of the same LARBED stack, each projected by first shifting all the frames in proportion to the frame's beam tilt prior to integration.

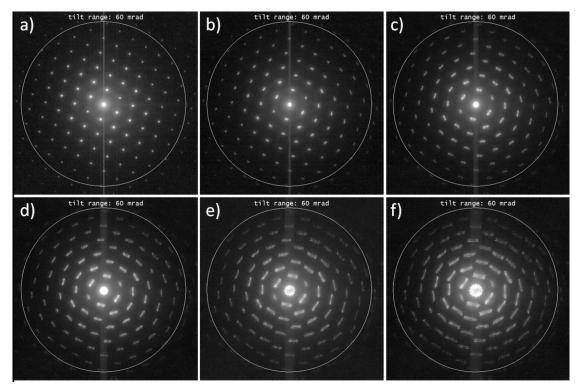


Figure 42: Different projections of a LARBED data stack recorded with full descan (**scan compensation** = 1) and a tilt range of 60 mrad (large circle superposed on each of the patterns). Pattern a) is equivalent to a simple stack integration and has been created by setting the scale of the diffraction disc to 0 pixels/mrad, and for pattern f) the diffraction disc scale was 0.2 pixels/mrad. Figures b) through e) correspond to equi-spaced intermediate diffraction disc scales between 0.04 and 0.16 pixels/mrad.

Figure 43 shows a screen shot of the **Reconstruct LARBED Pattern** command applied to a LARBED data stack (for producing the patterns shown in Figure 42). It is advised to align the data stack prior to executing this command (not always – see next example for extending the range of diffraction patterns for amorphous material). If the data has not been aligned the user will be prompted with a warning. The user may then select a scale for the circles, discs, or squares in pixels per mrad, depending on which scan pattern the data has been acquired with. Setting this value to 0 will produce the same pattern as the **Integrate Stack** command. Leaving the default value will produce a pattern that appears as if no descan would have been applied at all. Setting this scale to, for example, 1/10 of the default value will produce a LARBED pattern in which the size of the scan pattern is down-scaled by a factor of 10, as is approximately the case in Figure 42f.

Once the scale of the diffraction pattern has been defined, the user is asked to define a threshold for the noise level, i.e. CCD counts below which data should not be included in the summation. If no such threshold shall be applied to the data, leaving the default value of 0 is fine.

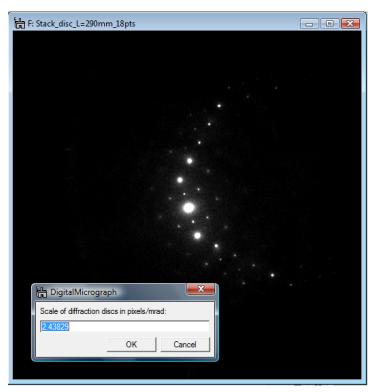


Figure 43: Screen shot of the **Reconstruct LARBED Pattern** command in action, results of which are shown in Figure 42. The initial value for the diffraction disc scale shown in the window corresponds to the scale, with which the data was acquired, i.e. applying this scale will make the diffraction discs as large as the white circles shown in Figure 42.

It is interesting to note that if the individual frames are shifted before being summed up, this shift enlarges the size of the reconstructed LARBED pattern. In some cases leaving the default value for the scale of the scan pattern (in pixels/mrad) may be very useful, as illustrated by the following example. Figure 44 shows how a large diffraction pattern may be assembled by a set of smaller ones, and, at the same time, the central beam has not been recorded (virtual beam stop). Here, the acceptance angle of the energy filter has been extended by compiling a larger diffraction pattern from a set of zero-loss filtered patterns covering a reciprocal space only about half as large.

For data like that shown in Figure 44 it is important to use the binary mask on each data frame in order to get a correct normalization factor. The similar mask that has been applied during acquisition may be used during reconstruction. Otherwise the averaging will be performed wrongly, resulting in a pattern like the one shown in Figure 44c. The position of the mask may be specified in two ways: a) by defining a threshold value, expecting that all intensity values within the aperture are above and those outside it below this threshold, or b) by defining (and selecting) a circular annotation in the data stack as shown in Figure 45.

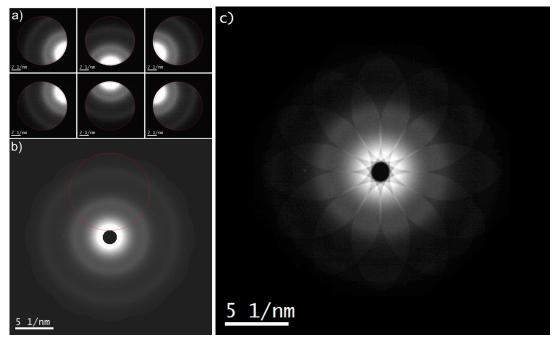


Figure 44: Reconstruction of a zero-loss filtered diffraction pattern of amorphous carbon from a LARBED data stack comprised of 12 partial patterns, each recorded with a large filter entrance aperture in place, blocking the central beam. a) 6 patterns out of 12. The circular annotation used to identify the area of interest has been superimposed on the data. b) Reconstructed pattern including normalization. c) Reconstructed pattern without applying normalization. Note that, depending on how much each of the diffraction patterns is shifted the reconstructed pattern has also more pixels than the original data.

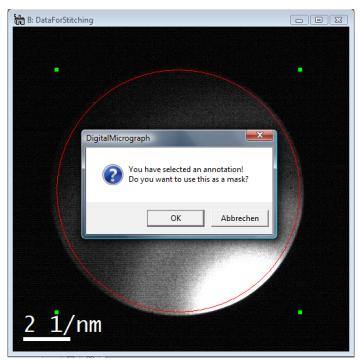


Figure 45: Screen shot of the **Reconstruct LARBED Pattern** command applied to a LARBED stack of amorphous carbon acquired with a large filter entrance aperture in place. The red circular annotation masks the range of valid data to be used for the reconstruction. Note that the annotation must be in the selected state in order to have any effect.

8.8. Reconstruction of CBED data stacks (**Reconstruct CBED Pattern**):

As described in section 6.4, the illumination can also be chosen to be convergent during the acquisition of the tilt series. Convergent beam electron diffraction (CBED) patterns may contain many details if the specimen is sufficiently thick. If the convergence angle is chosen small enough such that the discs of each of the CBED patterns do not overlap, but the change in beam tilt between successive tilts is small enough, then a composite CBED data set can be constructed, with each discs being stitched together from the individual CBED discs. This can simultaneously be done for multiple reflections. The registration of the discs may also be refined during the reconstruction, since for sufficiently small differences in beam tilt, discs corresponding to the same reflection but slightly different beam tilt share part of their features.

The reconstruction of the CBED pattern works, in principle, exactly the same, as that of a spot LARBED data stack. However, since each reconstructed diffraction disc (or ring, or square) contains a very large number of relevant data points, the individual diffraction discs are stored as separate frames in a 3D data stack. As shown in Figure 46a, reflections that are supposed to be considered during reconstruction must be identified using circular (oval) annotations. There exists also the option to also align the discs relative to one another. In order to make the alignment as robust as possible, the patterns are not added in the sequence they are acquired, but in order of increasing tilt. Note that this does not change the collection procedure at all. This results in a sequence somewhat resembling a spiral shape.

During alignment the discs may only be shifted by a specified maximum number of pixels (e.g. 2, as used in the example shown in Figure 46d) relative to the position they would be placed without trying to optimize the registration. By registering the discs with increasing tilt angle the reconstruction algorithm can somewhat predict the alignment of the discs at higher tilt angles, requiring only small corrections for their actual positioning. So as shown in Figure 46d and Figure 46e the shift applied to each of the patterns may easily exceed several tens of pixels, even though a very small maximum shift is specified. In most cases a maximum shift of 2 pixels is sufficient.

The composite CBED (or LARCBED) reconstruction considers the contrast in multiple reflections when aligning the discs. This means that even if the BF discs may be quite featureless, if there is some strong contrast in one of the DF discs, then this contrast will strongly contribute to the accurate alignment. This makes the alignment more robust than using just a single reflection. However, having said that, there is, of course, room for improvement: a shift in the disc position due to deviations of the specimen surface normal from the optic axis is not taken into account yet. This will be included in a future version.

Figure 46 illustrates the different steps of the CBED reconstruction:

- 1. Make sure the pattern is well aligned and display the pattern in such a way that the relevant reflection can easily be identified (e.g. by showing the sum of all frames this can be done by moving the 'width' slider in the *Slice Tool* to its maximum.)
- 2. Identify all the reflections, including the undiffracted beam, to be reconstructed by oval (circular) annotations (as shown in Figure 46a). Then, the annotation for the undiffracted

beam should be selected. The annotation that has been selected defined the origin of the diffraction space for this reconstruction, and the size of that particular annotation will be used as a discs mask (i.e. only the signal inside the area defined by the annotation will be taken into account - see below for a discussion on the proper disc mask size).

- 3. Click the corresponding menus item in the QED menu (*Reconstruct CBED pattern*). A little GUI will appear which allows to turn the discs registration on, or off, and also allows a maximum beam tilt for the data to be defined, as well, as the maximum number of pixels that these discs can be shifted (see inset in Figure 46d).
- 4. Press the *Start Reconstruction* button for starting the reconstruction. Depending on the number of patterns in the data stack, as well as the maximum shift defined for the reconstruction (the default value '2' seems a good choice in many cases), this reconstruction may take a bit of time. The reconstruction can be stopped at any time by simply pressing the same button again, which now should show the label '*Stop Reconstruction*'.

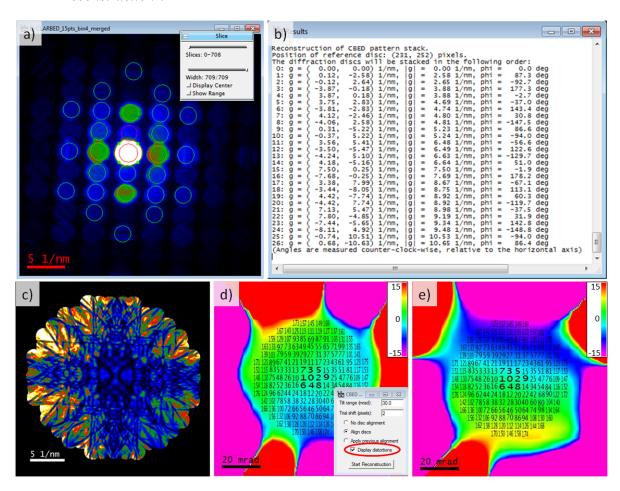


Figure 46: a) CBED data stack with discs selected for the reconstruction. The annotation identifying the central disc has been selected. Its position defines the origin of reciprocal space for this reconstruction, and its size defines the mask that will be used for defining the signal that is considered 'disc'. b) If multiple reflections are selected, the position of each reflection will be written in the results window in the sequence in which they appear in the data stack. c) An example reconstruction from the data shown in Figure 34 and Figure 35. However, a tilt range of 30 mrad (see also the right half of) has been defined. This will exclude some of the high tilt data. d) and e)

real and imaginary part of the complex image generated when selecting 'Display distortions'. The real part shows the shift (in pixels) along the horizontal direction that is applied to the different discs, and the imaginary part shows the shift along the vertical direction. The numbers show the different tilt angles that have been contributing to the composite CBED pattern, in the sequence in which they have been selected during the reconstruction.

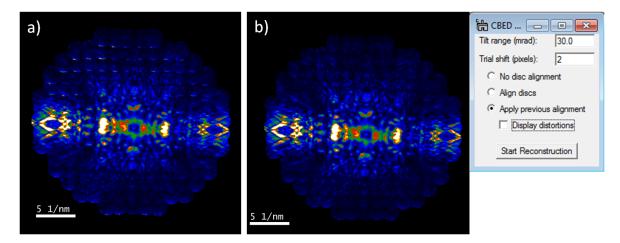


Figure 47: Illustration of the effect of mask size on the signal for the reflection just 'above' the central disc (shown as red circle in Figure 46a): a) If a large mask is used then the strong signal from the undiffracted beam may 'leak' into the reconstruction. b) Doing first a reconstruction with a mask as large as used in (a) and then choosing the option 'Apply previous alignment' when repeating the reconstruction with a smaller mask strongly reduces such 'leaking' artifacts but keeps the robustness of doing the alignment with a large mask and thus more overlap between adjacent discs.

8.9. Dealing with large data sets (Merge Split Data Stacks):

Most online installations of DigitalMicrograph are still running on 32-bit Windows systems and have severe limitations in the amount of memory that the system can allocate. This is why QED facilitates the acquisition of split data stacks. The acquired data may be processed offline on a computer which can allocate more memory (e.g. a 64-bit system). The **Merge Split Data Stacks** function allows such split data stacks to be combined into a single data stack again. Calling this menu function will ask the user to select the first partial data stack of the data set (see Figure 48). The function then automatically selects the remaining data sets and merges them all into one large data stack, preserving also all the information necessary to perform any of the other data analysis steps.

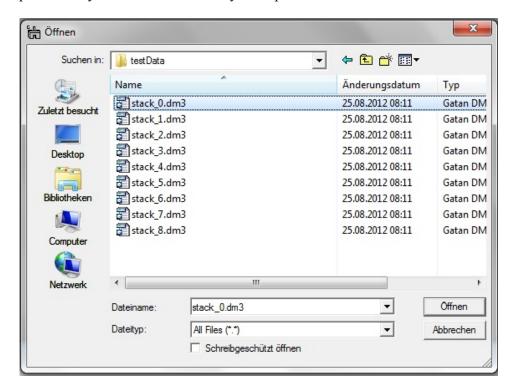


Figure 48: When calling the **Merge Split Data Stacks** function the first .dm3 file of the set of files should be selected. QED will automatically select the other files belonging to this data set.

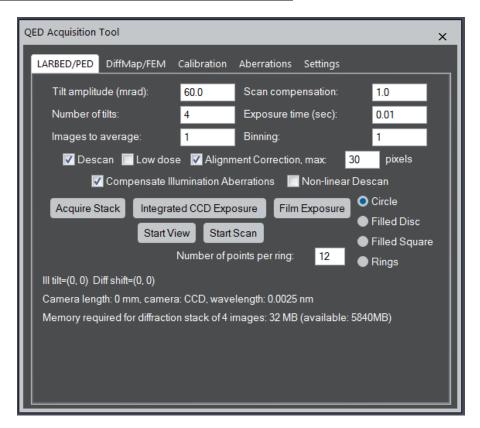
QED Quick Reference Guide

The QED Main Menu	QED Acquisition
	Define Origin
	Merge Split Data Stacks
	Align Stack
	Undo Stack Alignment
	Display Rocking Curve
	Print Rocking Curve
	Integrate Stack
	Reconstruct LARBED pattern
	Reconstruct CBED pattern
	Help
	About QED

Command	Description
QED Acquisition	This opens the QED Acquisition GUI (see below for details)
Define Origin	This defines the center of a diffraction pattern or diffraction data stack by locating the brightest pixel within an area selected by the user using a rectangular ROI.
Merge Split Data Stacks	Merges data stacks which have been saved in smaller sub-stacks into one large data stack.
Align Stack	This function automatically aligns stacks of diffraction patterns or images by tracking a well-recognizable feature. For LARBED or PED data stacks it is suggested to select the central beam using a rectangular ROI, since this will change the least with beam tilt (another feature must be selected if a beam stop has been used). Calling this function with the <i>Alt</i> -key held down will popup the input dialog that allow the user to specify a maximum shift.
Undo Stack Alignment	This command restored the original data stack even after the data stack was aligned by the Align Stack command.

Display Rocking Curve	This function will display:
	- The 2D or 1D rocking curve of diffraction data stacks,
	- A local diffraction pattern of the selected region in the case of DiffMaps acquired with a disc- or square shaped scan pattern,
	- An azimuthally integrated 1D diffraction profile in the case of FEM (fluctuation electron microscopy - a ring scanned DiffMap), or
	- A plot of the fixed-tilt directional local diffraction intensity in case of a DiffMap with a circular scan pattern.
	The resulting plots or 2D patterns will be updated live, when the user-selected ROI is moved or re-sized.
Print Rocking Curve	This function writes the information that would be displayed by the <i>Display Rocking Curve</i> function to the Results window.
Integrate Stack	This function integrates the 3D (PED/LARBED) data stack to create a 2D projection.
Reconstruct LARBED pattern	This function computes a 2D LARBED pattern after shifting each of the recorded frames by a user specified amount.
	This function may be used to compile a larger diffraction pattern from a set of smaller diffraction patterns.
Reconstruct CBED pattern	This function computes Large Angle CBED patterns from the rocked-beam CBED data stack after shifting individual CBED discs.



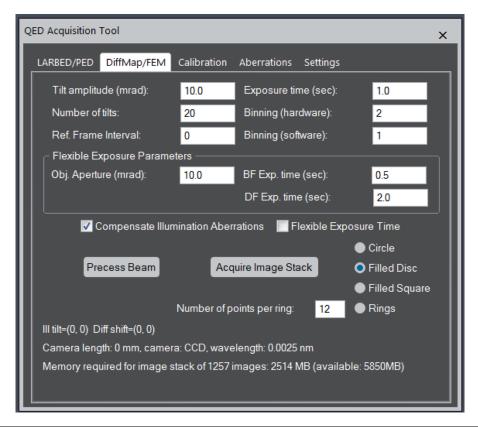


Command	Description
Tilt Amplitude (mrad)	The maximum beam-tilt angle corresponding to the radius of a circular scan pattern, half the width and height of the square scan pattern, or the radius of a precession circle.
Scan compensation	This specifies the relative portion of the beam tilt that will be compensated by the tilt de-scan. This value only applies when the de-scan is turned on. Setting this value to 1 will result in a classical PED pattern.
Number of tilts	Number of individual beam tilts around the circle in the case of circular scan patterns. For a disc-shaped scan pattern this specifies the number of tilts used to sample the disc radius. A square pattern will be sampled by (2N+1) beam tilts where N is the number of tilts. For a Rings pattern this specifies the number of concentric rings.
Exposure time (sec)	The exposure time used for individual CCD exposures or, in the case of exposing film, duration of individual beam tilt.
Images to average	Number of diffraction patterns that will be acquired and accumulated at each beam tilt.
Binning	Hardware binning applied when reading diffraction patterns from CCD.

Descan	This checkbox turns the de-scan on or off. If the de-scan is turned on it will be applied proportional to the beam tilt, scaled by the value given as the <i>Scan compensation</i> parameter.
Low dose	This checkbox applies mainly to the exposure of film (or image plates). If checked it will blank the beam between successive beam tilts, exposing the specimen for only the amount specified by <i>Exposure time</i> .
	For acquisition on a CCD camera the user should select the prespecimen blanker as a CCD shutter in order to minimize the dose on the sample.
Alignment correction	This turns on the de-scan correction for any imperfections and non-linearity in the (partial or complete) hardware de-scan by shifting the diffraction patterns to the proper position during the data acquisition. The maximum shift that will be compensated by this feature may also be specified. This value is the same as the one set in the <i>Settings</i> tab.
Compensate Illumination Aberrations	Ticking this checkbox will compensate for the tilt-induced beam shift, provided the illumination system has been calibrated.
Non-linear Descan	Specifies whether to use a simple linear de-scan calibration, or apply the calibration obtained when calibrating the shift-induced tilt.
Acquire Stack	Pressing this button will start the acquisition of a LARBED or PED data stack using the specified parameters.
Integrated CCD Exposure	Pressing this button will start the integration of the individual exposures at each beam tilt on CCD and obtain a LARBED or PED pattern in a single exposure.
Film Exposure	Pressing this button will acquire a PED or LARBED pattern on film. Because DM does not provide generic commands for film exposure this feature currently only works on Zeiss TEMs. Please contact us in case you are interested in acquiring such data on TEMs by other manufacturers.
Start View (Stop View)	This button starts a continuous CCD acquisition using the specified exposure time. The continuous acquisition will be stopped by pressing the same button (Stop View) again.
Start Scan (Stop Scan)	This button starts tilting and, if selected, compensating the beam tilt using all the parameters specified, just as for a regular exposure. However, no data will be acquired. The selected scan pattern will be repeated until the same button (Stop Scan) is pressed again.

Circle, Filled Disc, Filled Square, Rings	These radio buttons select between a simple circular precession (Circle), filled disc or square scan pattern (Filled Disc or Square), or a set of PED patterns with different precession angles (Rings). Note the difference in memory (shown at the bottom of this GUI) required for data stack acquisition in each of these modes.
Number of points per ring	This specifies the number of discrete beam tilt angles integrated over when acquiring the ring-shaped tilt pattern, e.g. for a sequence of PED patterns with varying precession angle. The number of concentric rings is specified by the <i>Number of tilts</i> parameter.

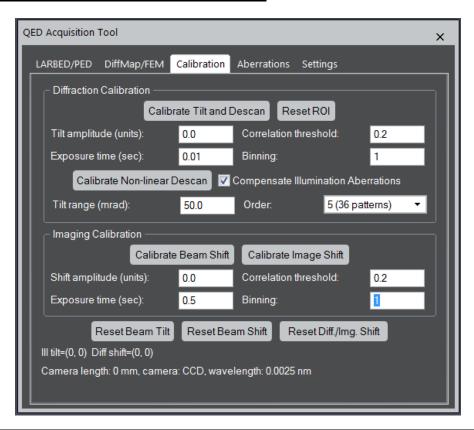




Component	Description
Tilt amplitude (mrad)	The maximum beam-tilt angle corresponding to the radius of a circular scan pattern or half the width and height of the square scan pattern, or the radius of a precession circle.
Exposure time (sec)	This specifies a fixed exposure time for all images that will be used in case the <i>Flexible Exposure Time</i> feature is NOT selected.
Number of tilts	Number of individual beam tilts around the circle in the case of circular scan patterns. For a disc-shaped scan pattern this specifies the number of tilts used to sample the disc radius. A square pattern will be sampled by (2N+1) beam tilts where N is the number of tilts. For a Rings pattern this specifies the number of concentric rings.
Binning (hardware)	Hardware binning used to acquire individual BF or DF images.
Ref. frame interval	Number of data images acquired between successive BF reference images used for drift compensation. If this value is set to zero, then no drift compensation will be done.

Binning (software)	In addition to hardware binning the acquired images may be binned further by software. Some CCD cameras support a maximum binning of 4. Software binning may then be used to reduce the data size of the final image stacks. Using a low hardware binning and high software binning also increases the dynamic range. Note that the image shift measurement and compensation is based
Obj. Aperture	on the as-acquired images, i.e. before applying software binning. Specify the size of the objective aperture here if you want the
BF Exp. Time (sec)	Flexible Exposure Time feature to apply. The software will use this exposure times for BF images for which the beam tilt is within the objective aperture.
DF Exp. Time (sec)	The software will use this exposure times for DF images for which the beam tilt is outside the range of the objective aperture.
Compensate Illumination Aberrations	If you are using a field-of-view limiting condenser aperture, you may want to tick this checkbox in order to keep the illumination stationary with tilt. For a very broad beam this is not necessary. This requires, of course, that the illumination system have been properly calibrated beforehand.
Flexible Exposure Time	Tick this checkbox if you want separate exposure times for BF and DF images to be used.
Precess Beam (Stop)	This button starts precessing the electron beam but without acquiring images. This feature may, for example, be used to check whether the sample is properly focused. You can stop beam precessing by pressing the same button (Stop) again.
Acquire Image Stack	This button starts the acquisition of DiffMap or FEM data stack using the specified parameters.
Circle, Filled Disc, Filled Square, Rings	These radio buttons allow the selection of the desired scan pattern for the acquisition of diffraction maps (see section <i>Diffraction Mapping</i> for details).
Number of tilts per ring	This specifies the number of discrete beam tilt angles that will be integrated over when acquiring data stacks with the ring-shaped tilt pattern. This may find application in Fluctuation Electron Microscopy. The number of concentric tilt rings is specified by the <i>Number of tilts</i> parameter.

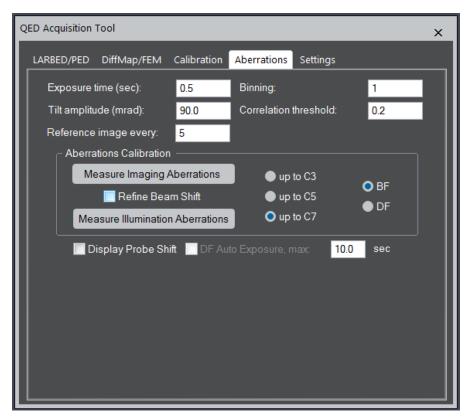




Component	Description
Calibrate Tilt and Descan	This button is one of the most important buttons of the whole GUI. It calibrates the beam tilt in mrad along X and Y and the diffraction shift necessary to compensate it.
Reset ROI	This resets the size of the region of interest (ROI) used to mark the area for tracking during the calibration routines to 1/8 of the size of the image and places the ROI to the center.
Tilt amplitude (DACs)	It is recommended to leave this value at zero since in that case a suitable value will be estimated automatically.
	In case you want a specific value to be used for beam-tilt calibration, you may enter the corresponding amount in DAC units here.
Correlation threshold (Diffraction/Imaging)	If the value of the correlation function used to measure relative image or diffraction pattern shift is below this value, the calibration routine will be aborted.
Exposure time (sec) (Diffraction/Imaging)	Exposure time used for acquiring diffraction patterns (in the <i>Diffraction Calibration</i> box) and images (in the <i>Imaging Calibration</i> box). Note that changing these values will also change the exposure times throughout this GUI.

Binning (Diffraction/Imaging)	This defines the hardware binning used for acquiring the calibration data. These may again be different for images and diffraction patterns. Changing these values will also change the hardware binning throughout this GUI.
Calibrate Non-liner Descan	This button starts a detailed calibration of the de-scan coils which is much more reliable than the simple linear de-scan calibration (obtained by <i>Calibrate Tilt and Descan</i>). If <i>Compensate Illumination Aberrations</i> is turned on, the tilt induced by shifting the beam on the sample is also compensated.
Compensate Illumination Aberrations	Selecting this option will apply the previously calibrated compensation of the illumination aberrations when calibrating the shift-induced tilt.
Tilt range (mrad)	This specifies the tilt range up to which the shift-induced tilt calibration shall be performed
Order	This selects the order of polynomial which will be fitted to the shift-induced tilt calibration.
Calibrate Beam Shift	This button starts the automated beam shift calibration routine necessary to perform the illumination aberration measurement. Start this with the sample removed from the beam and a small condenser aperture in place.
Calibrate Image Shift	This button starts the automated image shift calibration routine necessary to perform the imaging aberration measurement and drift correction during the acquisition of diffraction maps. Start this with an easily trackable feature on the sample at the center of the field of view.
Shift amplitude (DACs)	It is recommended to leave this value at zero since in that case a suitable value will be estimated automatically.
	In case you want a specific value to be used for image-shift or beam-shift calibration, depending on which of the two buttons is pressed, you may enter the corresponding amount in DAC units here.
Reset Beam Tilt	This button resets the beam tilt to the value it had before the QED Acquisition GUI opened. This may be handy in situation when some unforeseeable event (e.g. communication problem between TEM and DM or a DM error message during acquisition) has halted the acquisition procedure and leave the beam tilt off-axis.
Reset Beam Shift	This button resets the beam shift.
Reset Diff./Img. Shift	This button resets the image shift or diffraction shift, depending on the mode of operation of the microscope.

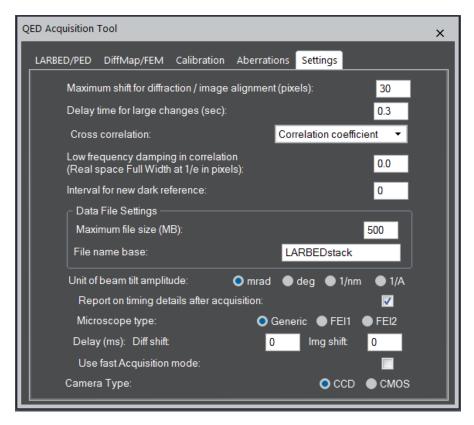




Component	Description
Exposure time (sec)	Exposure time used for acquiring all of the images used for fitting the pseudo aberration coefficients.
Binning	This defines the hardware binning used for acquiring the tilted images. Note that none of these images will be saved, so memory is not an issue here. However, a binning > 1 may increase the speed while sacrificing some accuracy.
Tilt amplitude (mrad)	Tilt amplitude up to which the tilt-induced image shift will be measured and the pseudo-aberration coefficients will be fitted. Note that a default value will automatically appear when the order of aberration coefficient is changed.
Correlation threshold	If the value of the correlation function used to measure relative image shift between two images is below this value, the aberration measurement will be aborted.
Reference image every	This specifies after how many tilted images the software should acquire a reference image (BF image) with the beam aligned along the optic axis. Recording a reference image frequently (e.g. every 5 frames) avoids the aberration calibration to be affected by specimen drift.

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Measure Imaging Aberrations	This button starts the automated routine for measuring the pseudo aberration coefficients of the imaging system. It should be run without a condenser aperture and an easily trackable feature in the field of view of the detector.
Refine Beam Shift	This option should be selected when iteratively refining the calibration of the illumination pseudo-aberration coefficients. It will apply the previously determined beam shift when measuring the imaging aberrations in BF mode.
Measure Illumination Aberrations	This button starts the automated routine for measuring the pseudo aberration coefficients of the illumination system. It should be run with a small condenser aperture selected and no specimen in the field of view.
up to C3,C5, or C7	This specifies the degree of aberration polynomial being fitted to the tilt-induced image shift. This also affects the number of images that need to be acquired to allow fitting the corresponding number of aberration coefficients. Changing this selection will automatically suggest a corresponding default value for the tilt amplitude. Please see section on <i>Measuring Microscope Pseudo-Aberration Coefficients</i> for further details.
BF or DF	Selects whether the calibration of the illumination pseudo- aberrations should be performed in bright-field (BF) or dark- field (DF) mode.
Display Probe Shift	Produces a graphical display of the beam shift induced by the illumination pseudo-aberrations, as well as a graphical indication of the beam tilt angles already measured during illumination aberration calibration.
DF Auto Exposure	Selects whether QED may automatically adjust the exposure time in DF mode when the intensity of the DF images becomes too low. Maximum exposure time up to which the auto exposure mode may increase is specified in sec.





Component	Description
Maximum shift for diffraction/image alignment (pixels)	This value specifies the maximum shift between successive frames in a 3D data stack of diffraction patterns or images that will be compensated by the QED stack alignment routine as well as the on-the-fly alignment functions for LARBED/PED and DiffMap/FEM acquisitions
Delay time for large changes (sec)	This delay time may be necessary to allow for the deflector coils drivers to stabilize and depends on the microscope manufacturer. It will only be applied after the <i>beam tilt</i> and/or <i>diffraction or image shift</i> have been changed by large amounts (i.e. during calibration or before and after changing to BF condition for acquiring a reference image in DiffMap/FEM mode).
Cross correlation	Cross correlation is used for calibration and aberration measurement. The mode of cross correlation can be selected from <i>Correlation coefficient</i> and <i>SSD/Chi2</i> . (SSD: Sum of Squared Differences)

Low frequency damping in correlation (Real space Full Width at 1/e in pixels)	This value specifies a width of the damping function (Gaussian) used to suppress low-frequency noise in the correlation map when aligning diffraction patterns and images. If a slowly varying feature is stronger than a true correlation peak, this option will work efficiently. However, you may have to change the correlation threshold in the Calibration and Aberrations tabs accordingly.
Interval for new dark reference	For the measurement of the illumination aberrations in DF-mode this value specifies the number of dark-field images which will be acquired before a new <i>dark-reference</i> will be obtained. On some CCD cameras the scintillator after-glow requires new dark-reference images to be acquired every 5-10 frames if the signal of interest is very faint.
Data File Settings Maximum file size (MB) File name base	If a data stack to be acquired exceeds the available memory (largest block of consecutive memory) or if a user wants to impose an upper limit on the size of data files produced by QED, it will be saved in blocks no larger than the <i>maximum file size</i> using file names which start with the name specified as <i>File name base</i> , appended by an integer index. The target directory will be specified by the user when starting the acquisition of a data set which requires saving in blocks.
Unit of beam tilt amplitude	Here the unit being used to specify the tilt amplitudes and angular cut-off of the objective aperture may be set up. Changing the unit will immediately change the values in all the affected GUI items.
Report on timing details after acquisition	Checking this box will print a detailed report on the time it took to move the beam and read the data from the CCD camera after each acquisition.
Microscope type	Select your microscope type. This is essential for FEI users.
	FEI1 and FEI2 correspond to a different diffraction shift command implemented in the EMControl (Gatan). You may want to try FEI2 first.
Delay (ms)	This delay time may be necessary to allow for the deflector coils drivers to stabilize and depends on the microscope manufacturer. It will be applied every time after the <i>Diffraction shift</i> and/or <i>Image shift</i> have been changed.
Use fast Acquisition mode	Checking this box will make a CCD read out faster.
Camera type	Select your camera type. This is essential for the CMOS camera.